

Chemistry with Droplets

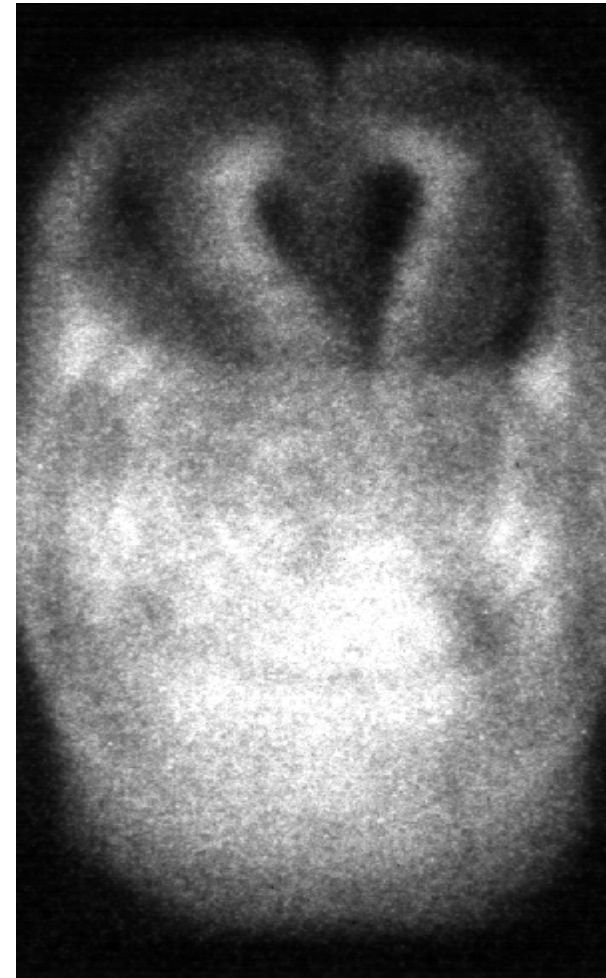
Han Gardeniers

MESA+ Institute for Nanotechnology

University of Twente

Summer School in Nanofluidics

ICTP, Trieste, Italy



A challenge in synthetic chemistry research

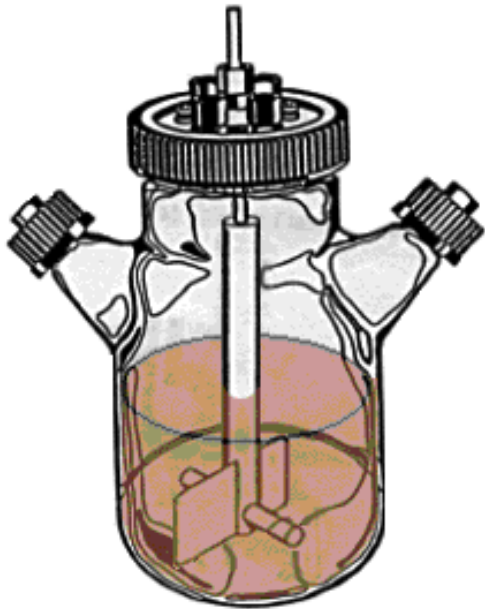
- In e.g. pharmaceutical research, there is a need to screen many many different chemical substances for their activity



- Down the line of medicine development, the production process for selected substances has to be optimized
- To save resources and the environment the volume of reactants, solvents and waste should be minimized
- So there is need for performing chemical reactions at as many different conditions as possible, in parallel, in small volumes.

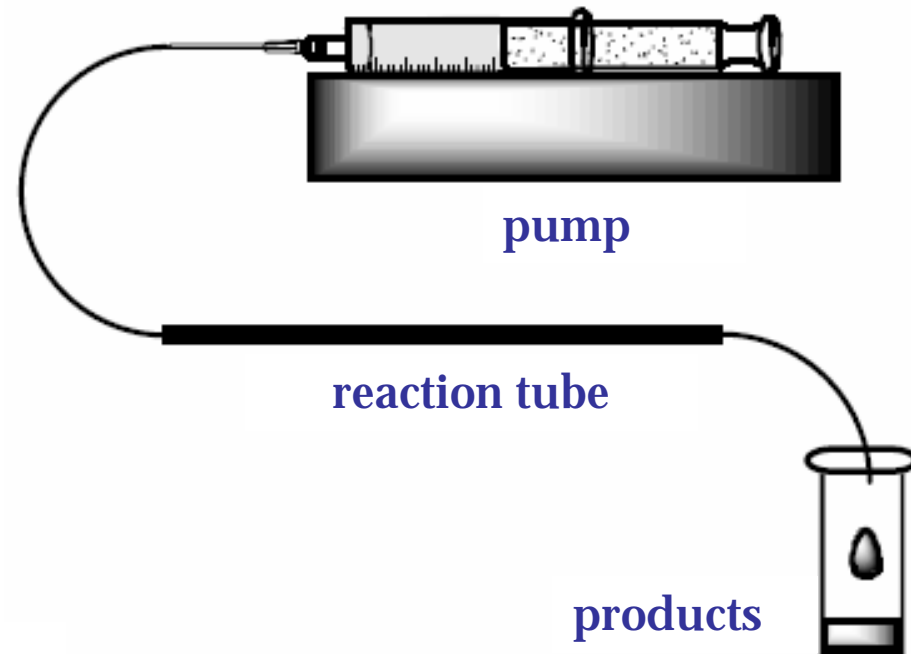
Basic reactor designs

batch

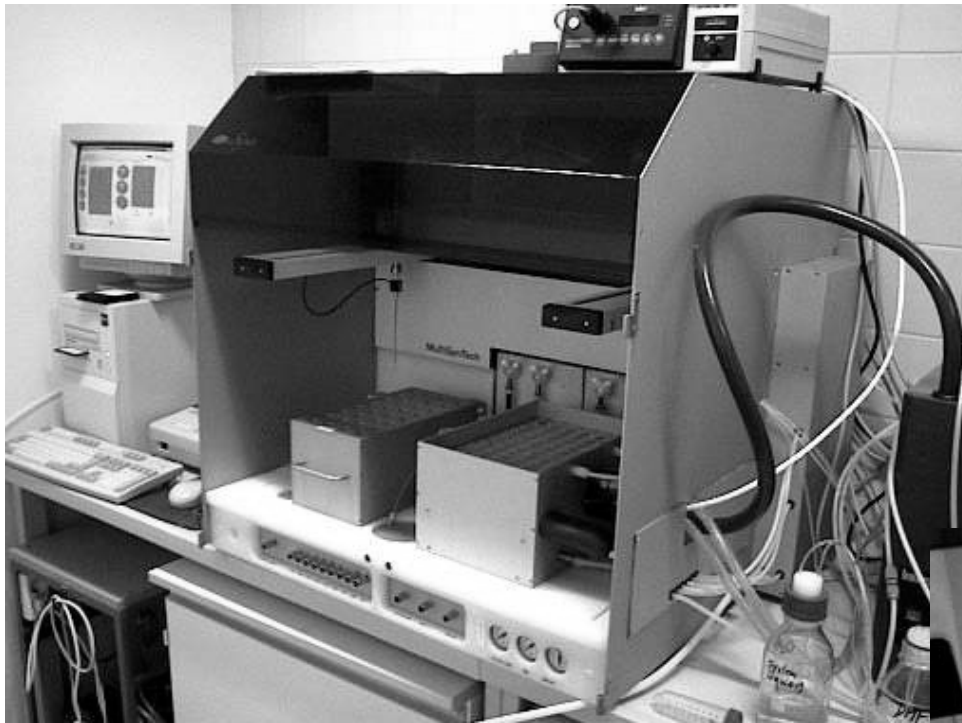


stirred continuously
products collected at end of proces

continuous flow



Small batch reactors in parallel



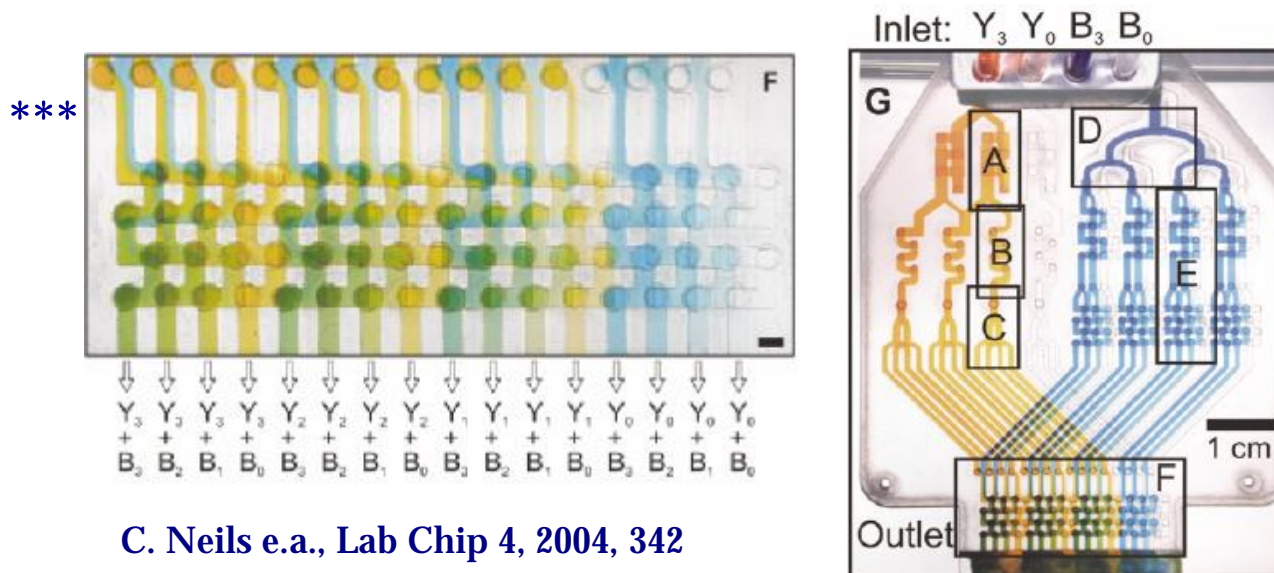
Synthesis Robot:

- Combination of Software and Hardware
- Reaction Block: -40 to 150°C, Filtration, Washing
- Programmed stirring
- Inert Gas / Vacuum / Pressure
- Fluid Handling



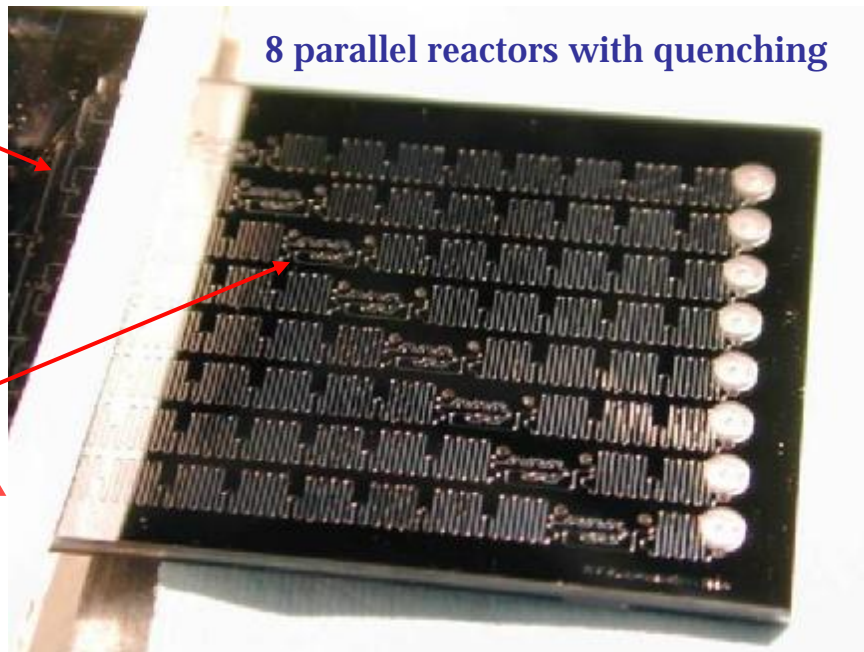
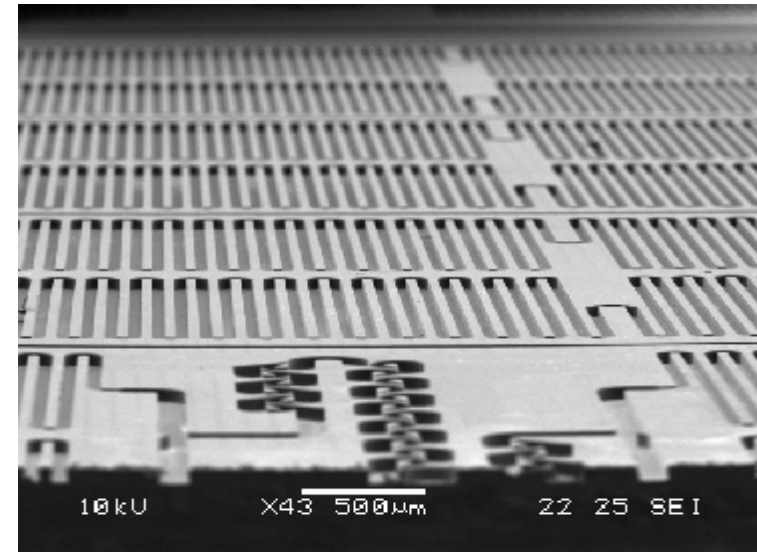
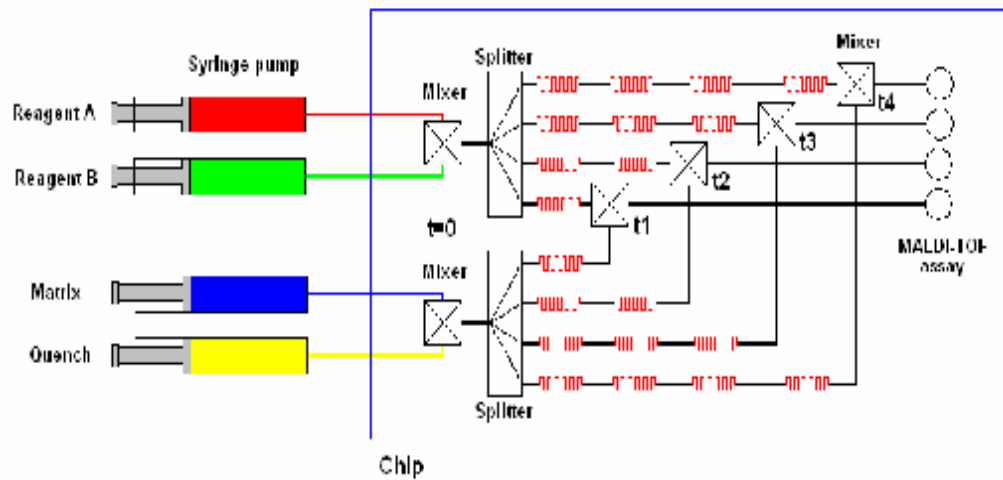
Chip-based microreactors

- complex microfluidic networks (e.g. for concentration series^{***})
- dangerous reaction conditions (high temperature, high pressure, toxic or explosive chemicals) can be tested safely because of small volumes and high heat transfer rates
- resources and waste are reduced
- a high surface-to-volume ratio helps when phase transfer or heterogeneous catalysis is involved



C. Neils e.a., Lab Chip 4, 2004, 342

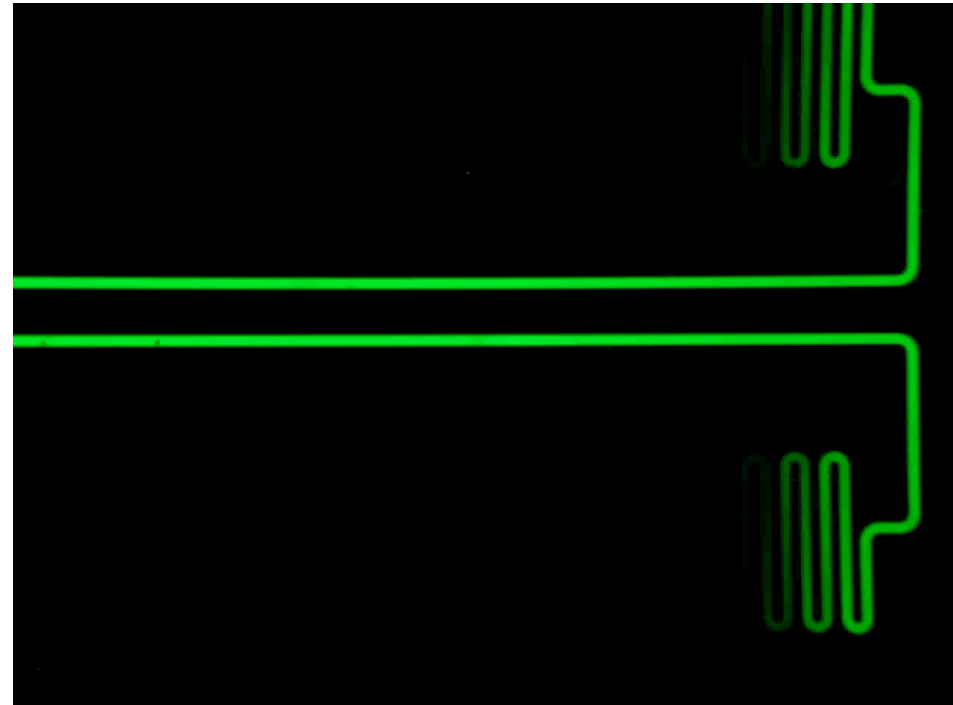
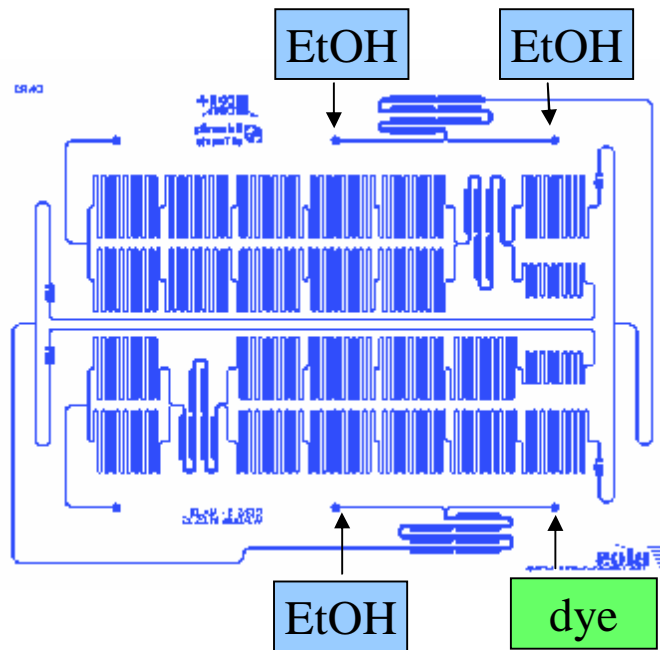
Reaction kinetic studies in parallel channels



typical feature size: 50 μm

W. Bula et al. IMRET9,
Potsdam, sept. 2006

Test of parallel-processing concept

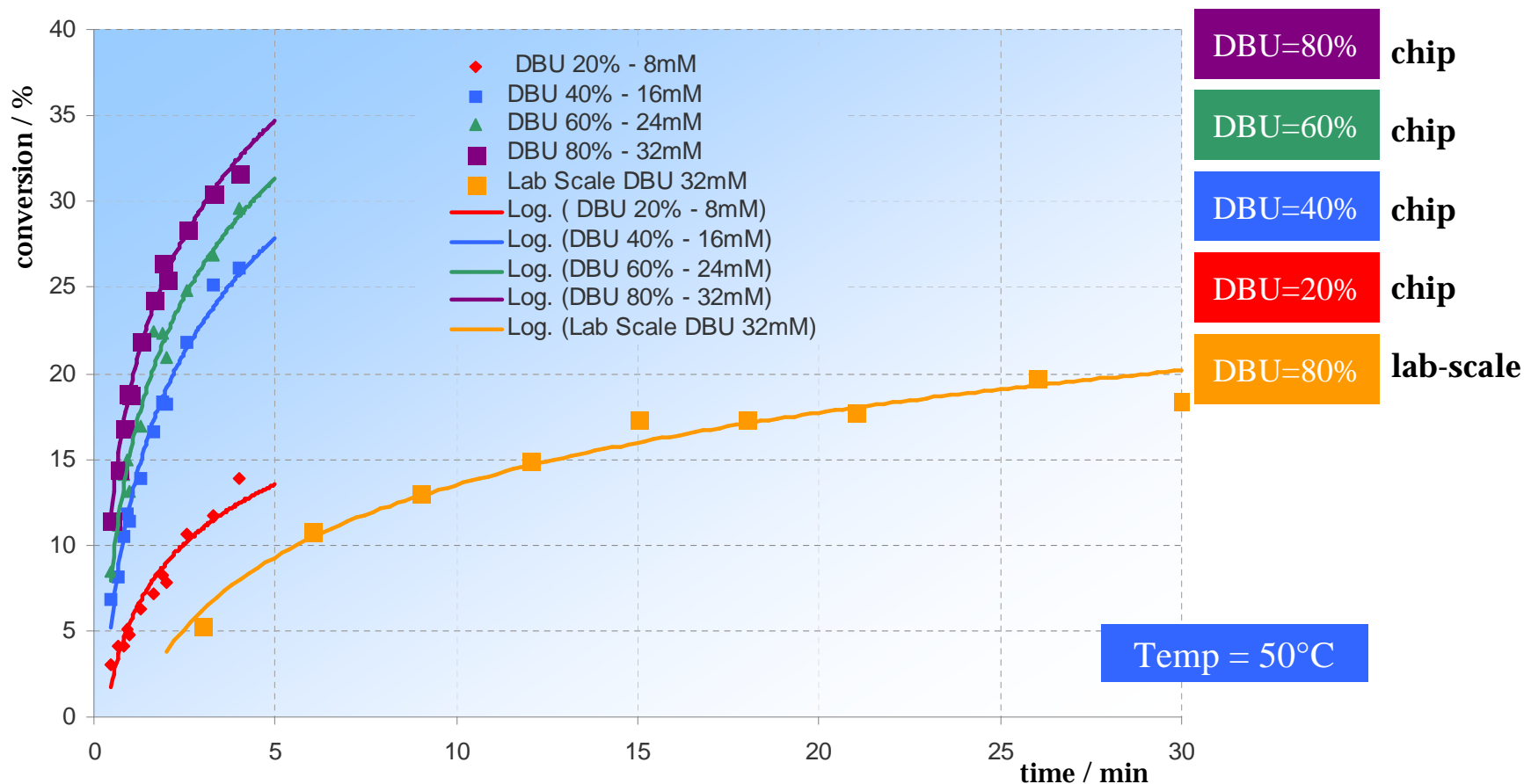
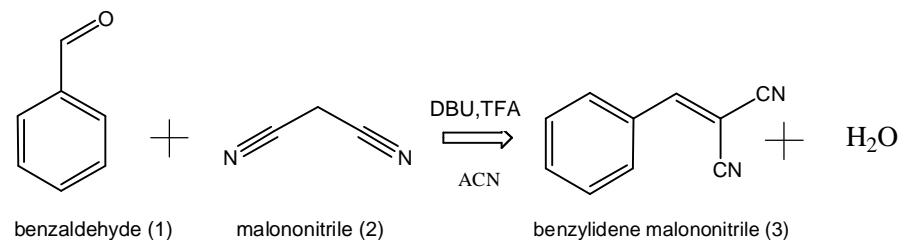


Transport of fluorescent dye plug through the chip. Total residence time ~ 1 min, flow rate $4 \times 0.4 \mu\text{L}/\text{min}$. Flow rate difference $\sim 3\%$.

This difference is caused by non-uniformity of silicon etching. Note that hydraulic resistance is proportional to the square of both channel depth and width. For example, a $1 \mu\text{m}$ variation on a nominal channel depth of $50 \mu\text{m}$ will give rise to 4% flow variation. A variation of 2% in etching rate over a 4 inch wafer is not uncommon and depends on feature size and locally exposed etched surface area (loading)

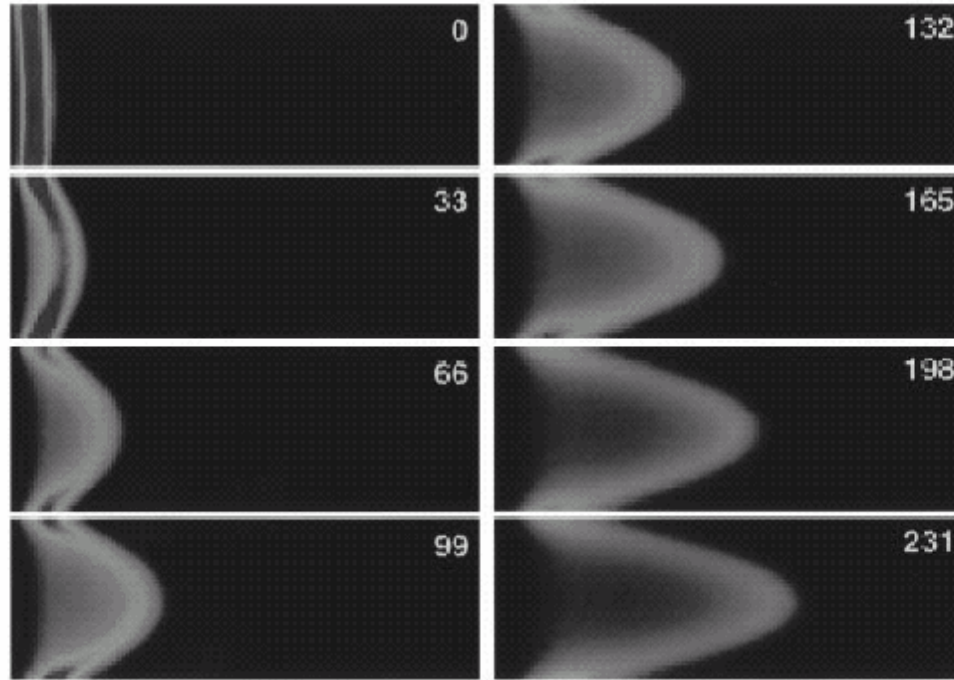
Reaction kinetic curves

Knoevenagel condensation / UV-Vis absorption



Note the much high conversion on the chip, compared to lab-scale: Is this an ideal plug flow reactor, do we measure intrinsic kinetics?

Axial (Taylor-Aris dispersion)

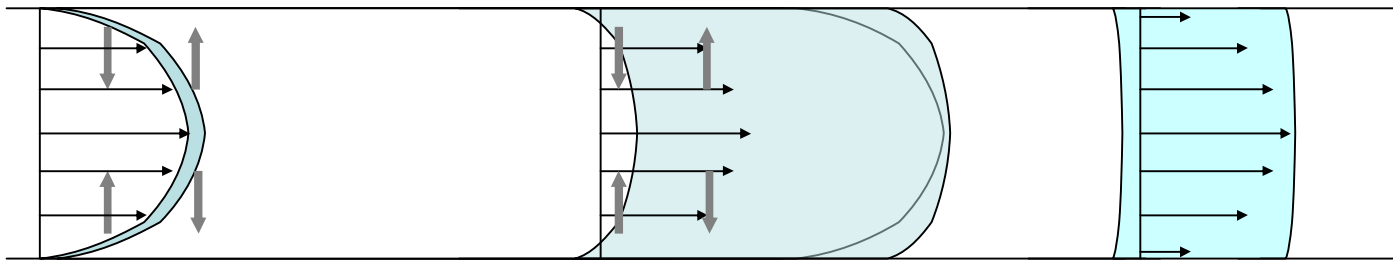


Parabolic flow profile in pressure-driven flow (short time-scale, numbers in ms)

From: Paul e.a. Anal.Chem. 70, 1998, p.2459.

After longer times*** diffusion "blurs" the parabolic shape

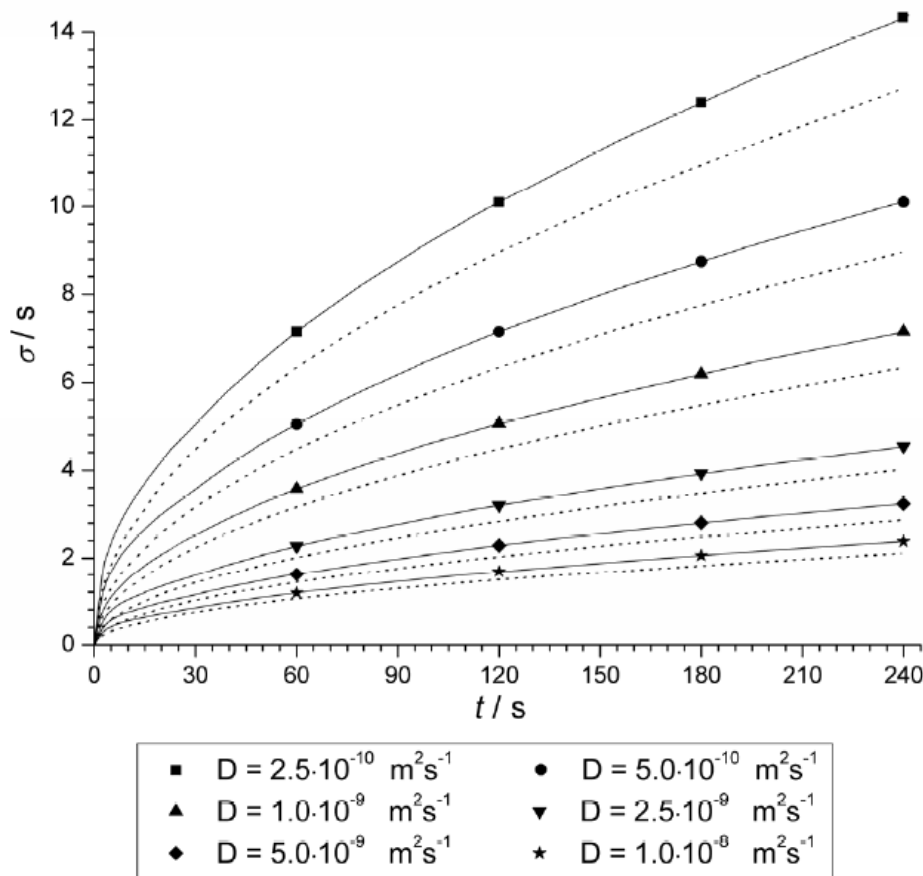
***For 50 μm wide/deep microchannel, radial mixing has occurred within ~ 1 sec



Axial dispersion in a microreactor

Taylor-Aris: axial concentration distribution evolves diffusively:

$$D_{eff} = D \left(1 + \frac{1}{210} \cdot Pe^2 \cdot f\left(\frac{d}{W}\right) \right) = D \left(1 + \frac{1}{210} \left(\frac{U \cdot W}{D} \right)^2 f\left(\frac{d}{W}\right) \right)$$

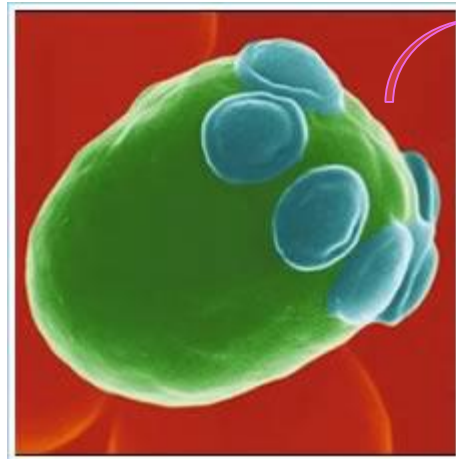


Plot of standard deviation in straight channel (dashed line) and in meandering channel (solid line) as a function of residence time for different values of the mass diffusion coefficient.

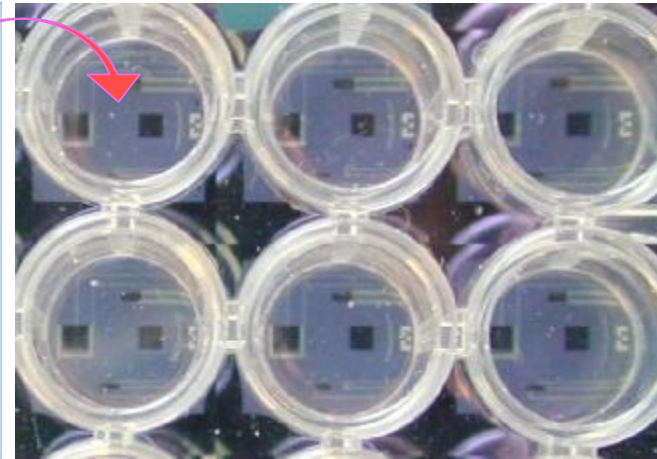
Typical dispersion: $6s/240s = 2.5 \%$

"Nanoreactors" in microreactors

cells (fermentation)



Saccharomyces cerevisiae



Micro titerplate with integrated sensors

two-phase systems

liquid-gas on a surface (batch)	liquid-gas in a microchannel (batch in flow)
liquid-liquid on a surface (batch)	liquid-liquid in a microchannel (batch in flow)

G-L flow patterns

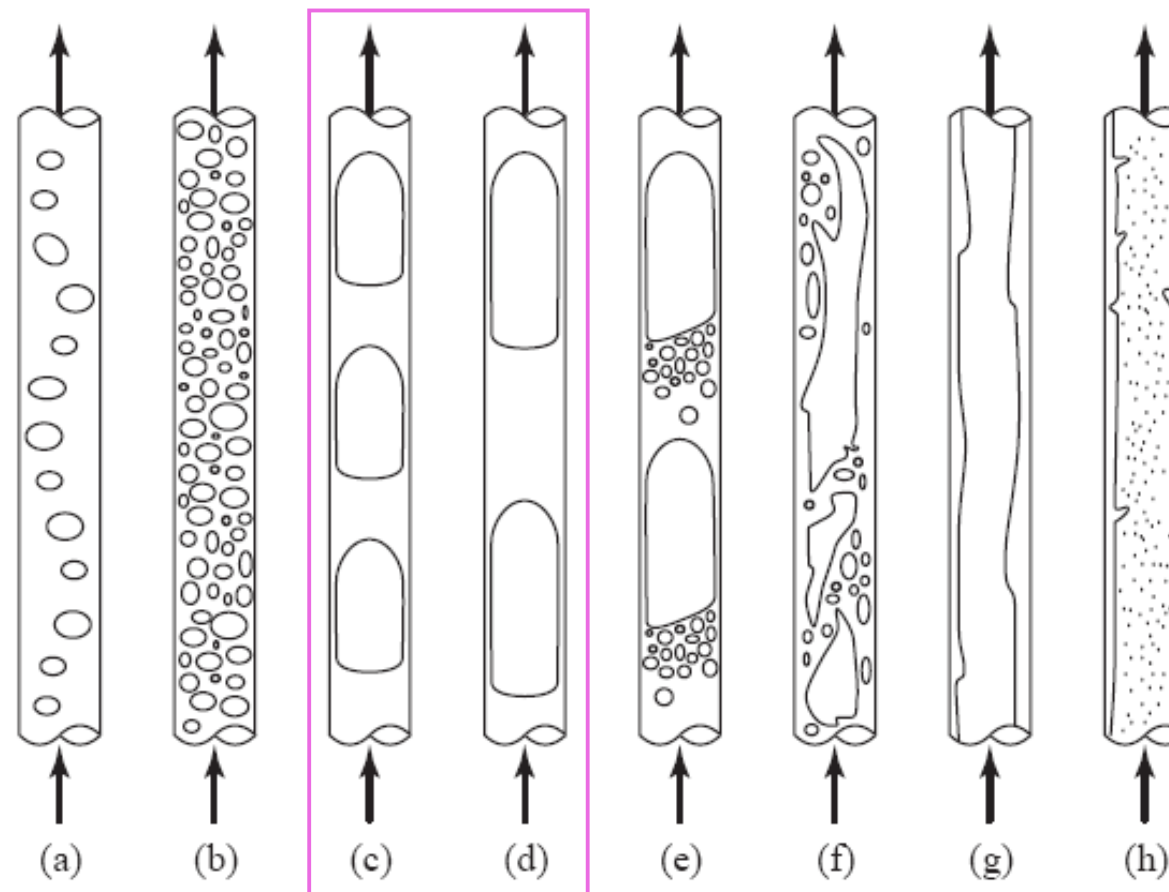
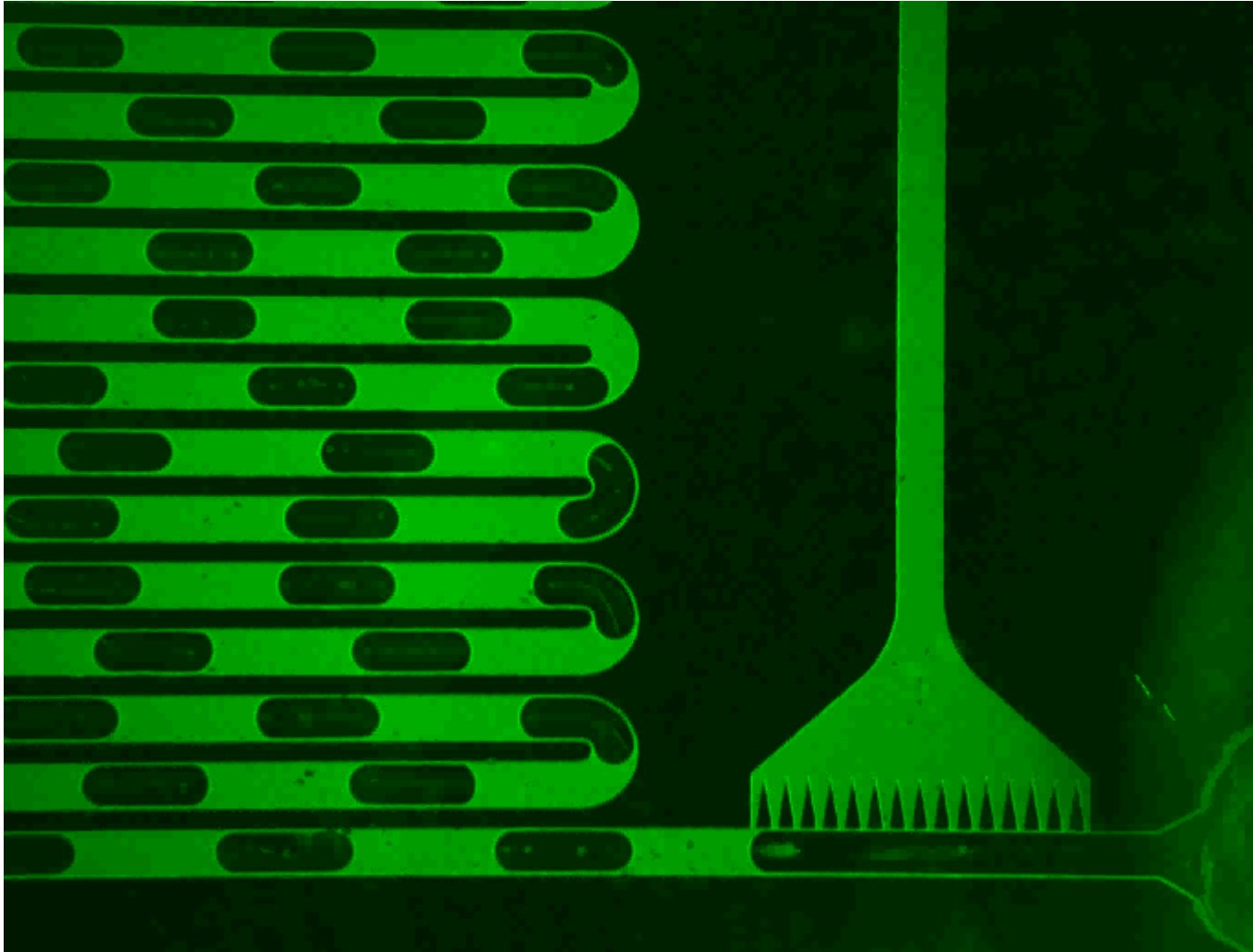


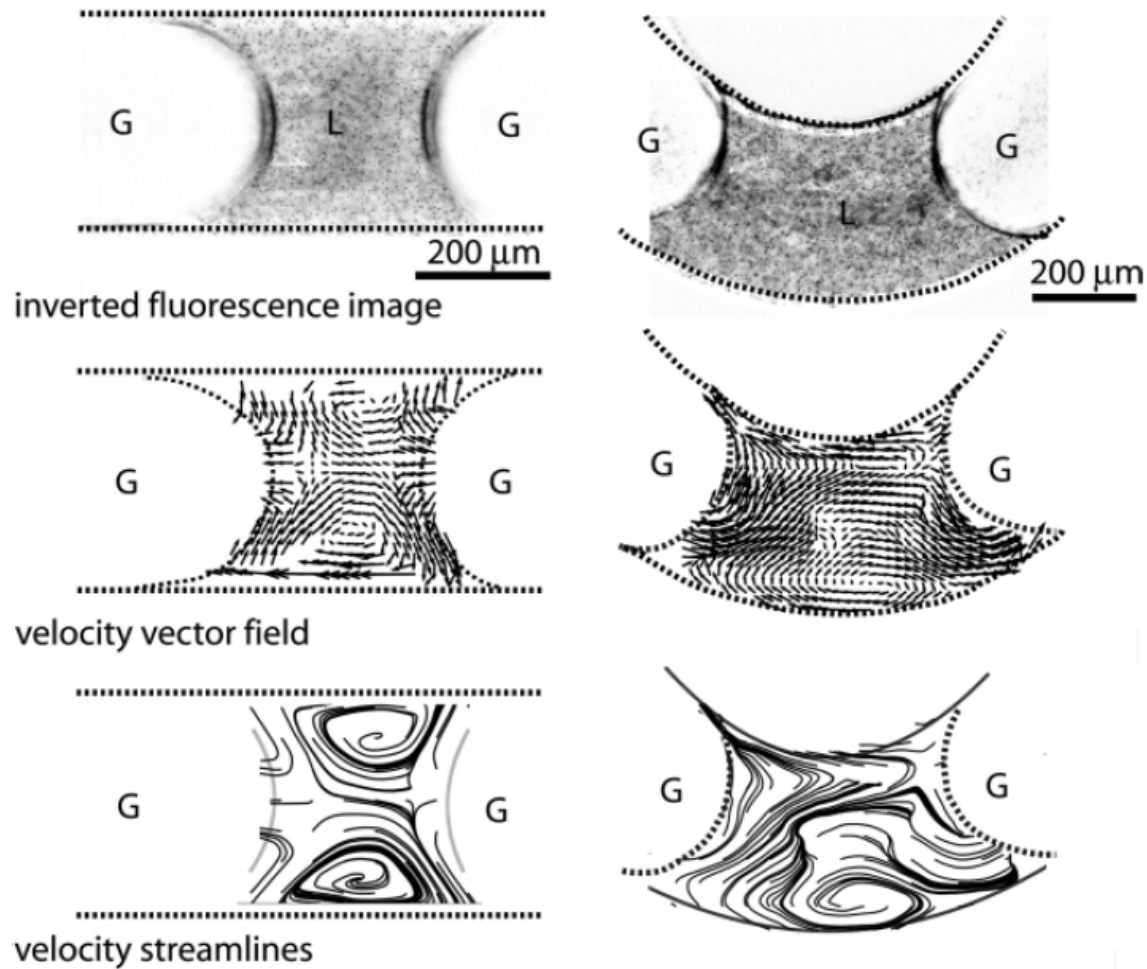
Fig. 1. Sketch of observed flow patterns in capillary channels. (a,b): bubbly flow, (c,d) segmented flow (a.k.a. bubble train flow, Taylor flow, capillary slug flow), (e) transitional slug/churn flow, (f) churn flow, (g) film flow (downflow only), (h) annular flow.

L-G, Taylor flow (slug flow)



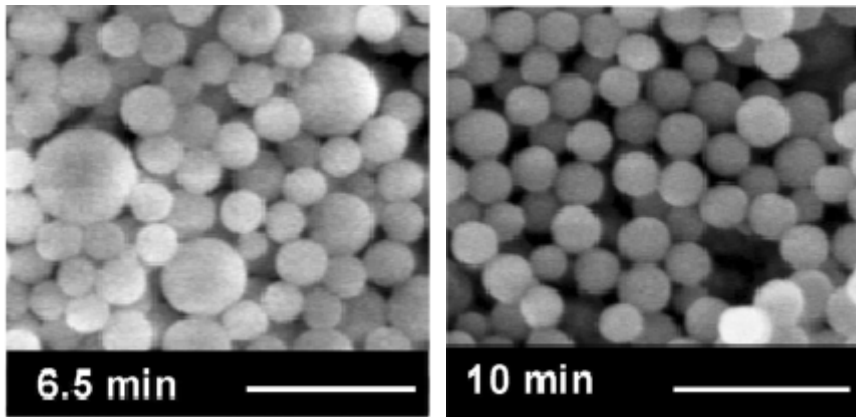
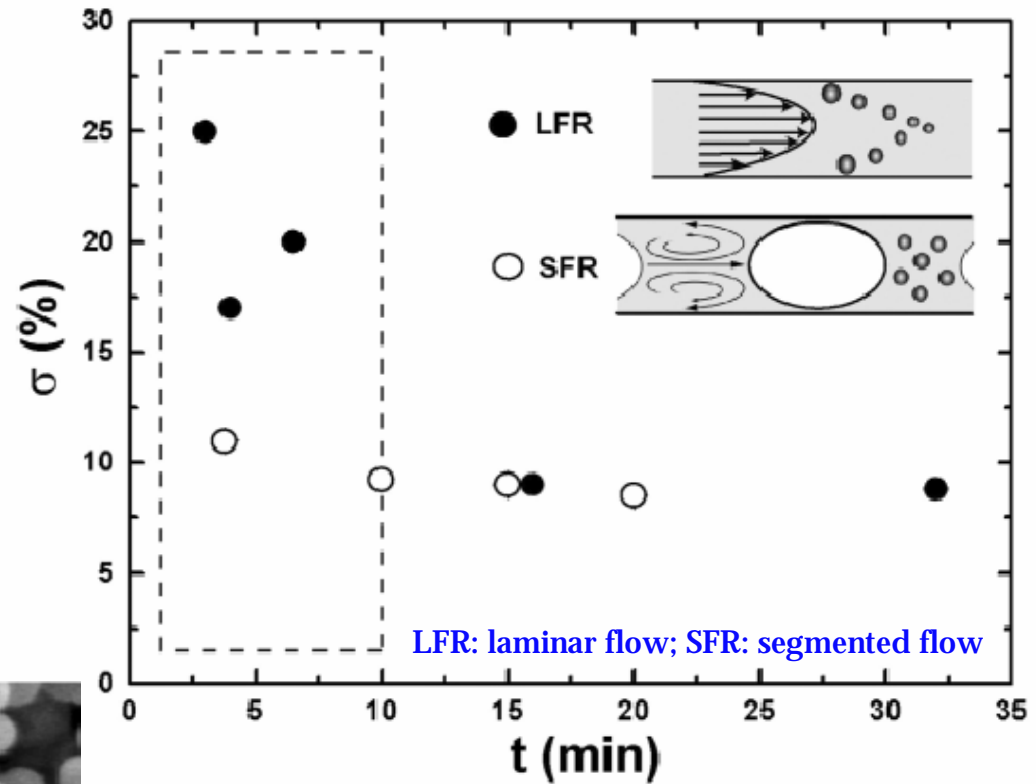
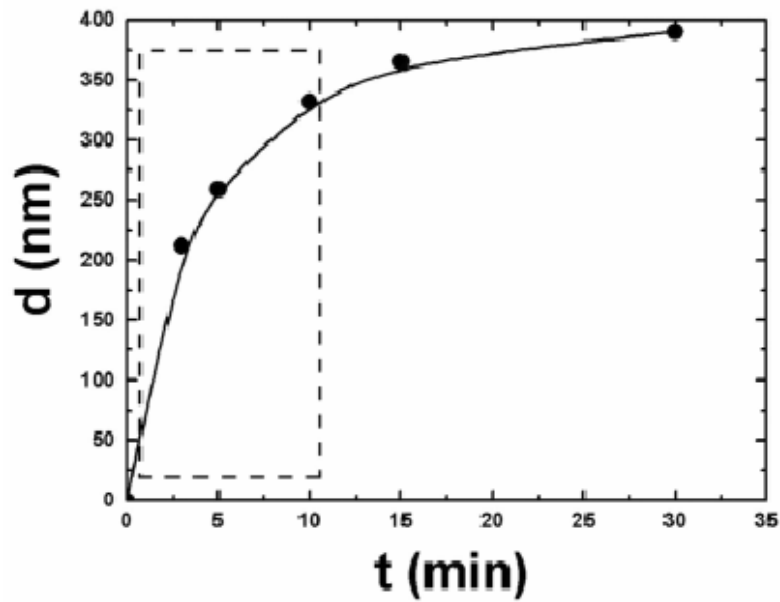
From: A. Günther e.a. Lab Chip4, 2004, p.278

Mixing inside slugs



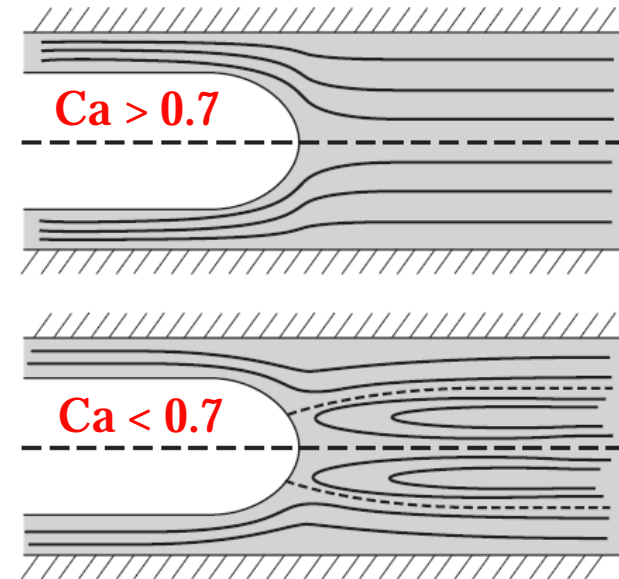
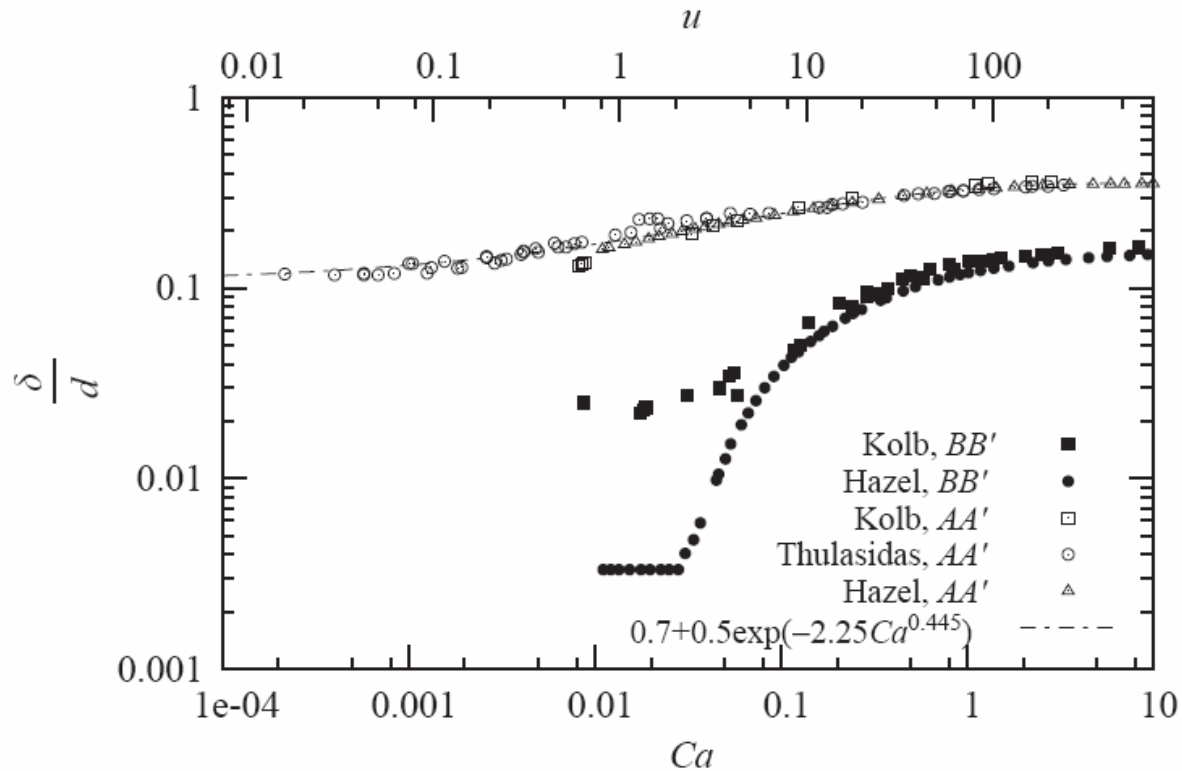
From: A. Günther e.a. Lab Chip4, 2004, p.278

Growth of nanoparticles in microchannels



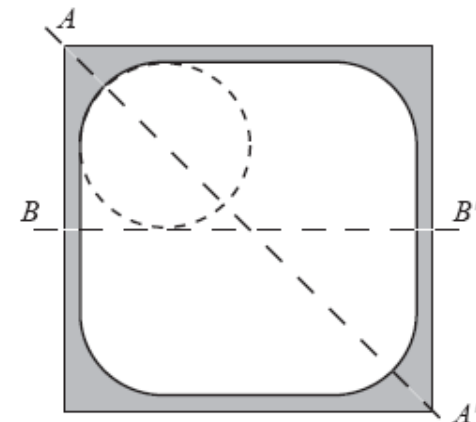
Silica nanoparticles. Scalebar 1 μm

Thin film in Taylor flow

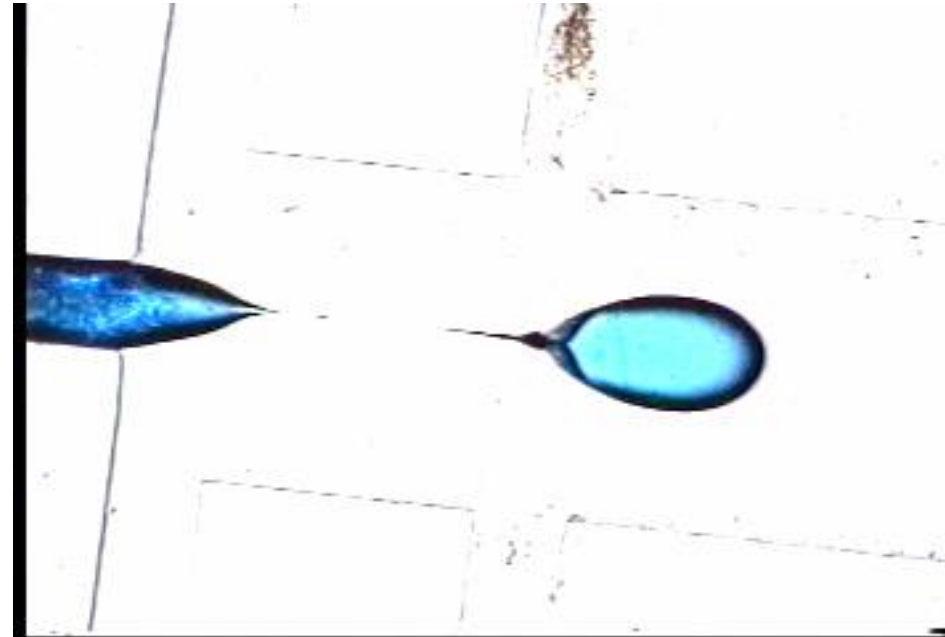


Relative film thickness δ (channel width d), for square channel, as $f(Ca)$ (calculation of u assumes water)

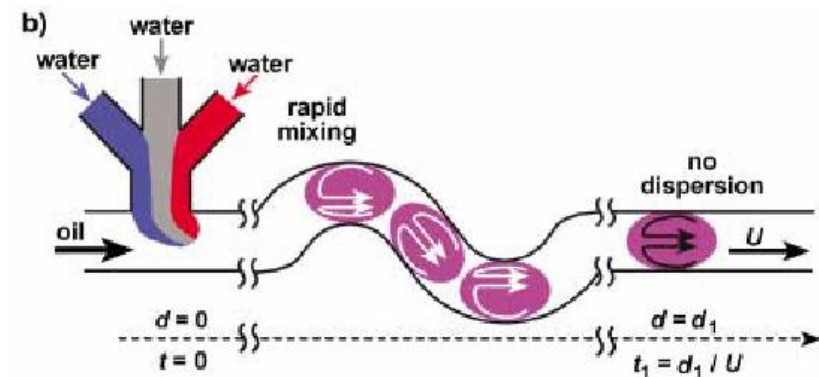
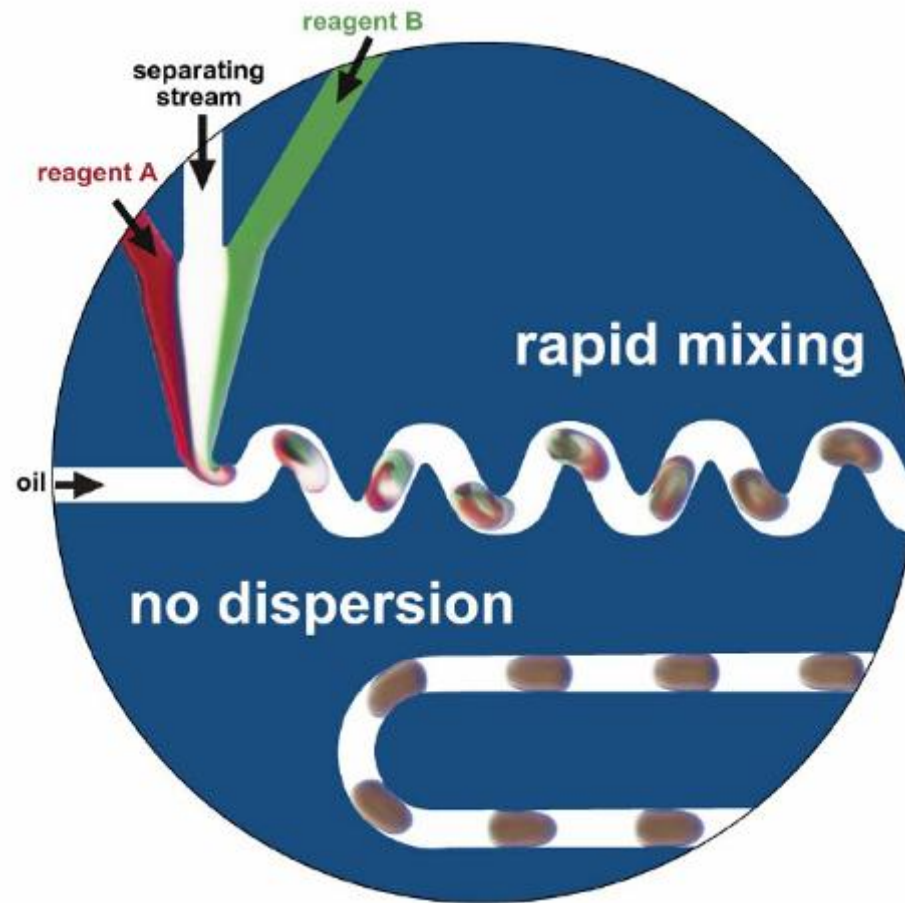
Capillary number $Ca = \eta u / \sigma$
with η viscosity, u velocity, σ surface tension



L-L, droplet formation in microchannels

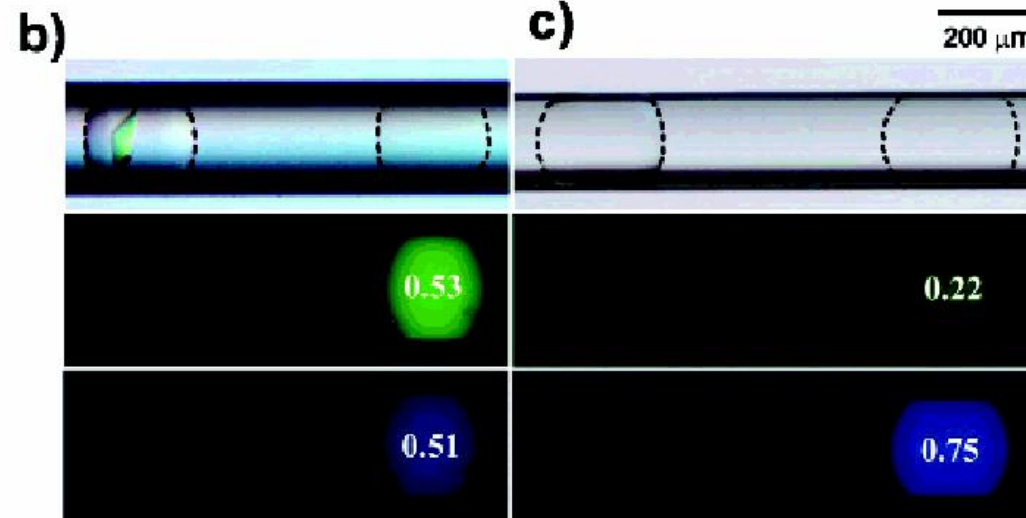
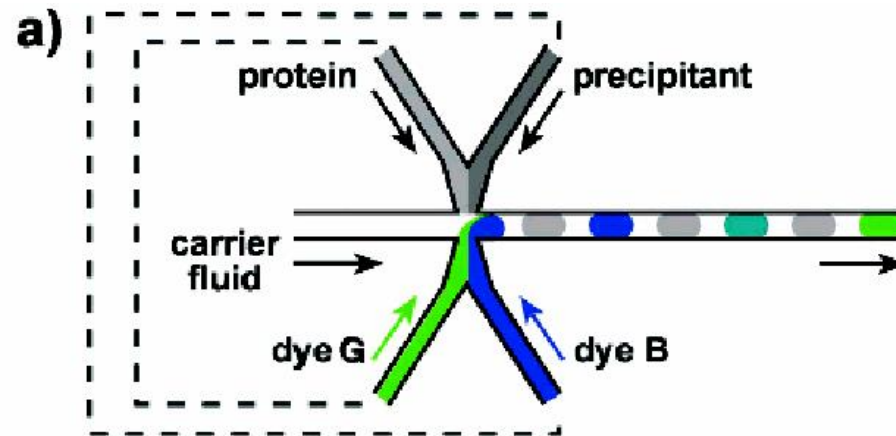


Time-periodic recirculating flow inside the droplets caused by the shearing interaction with the walls

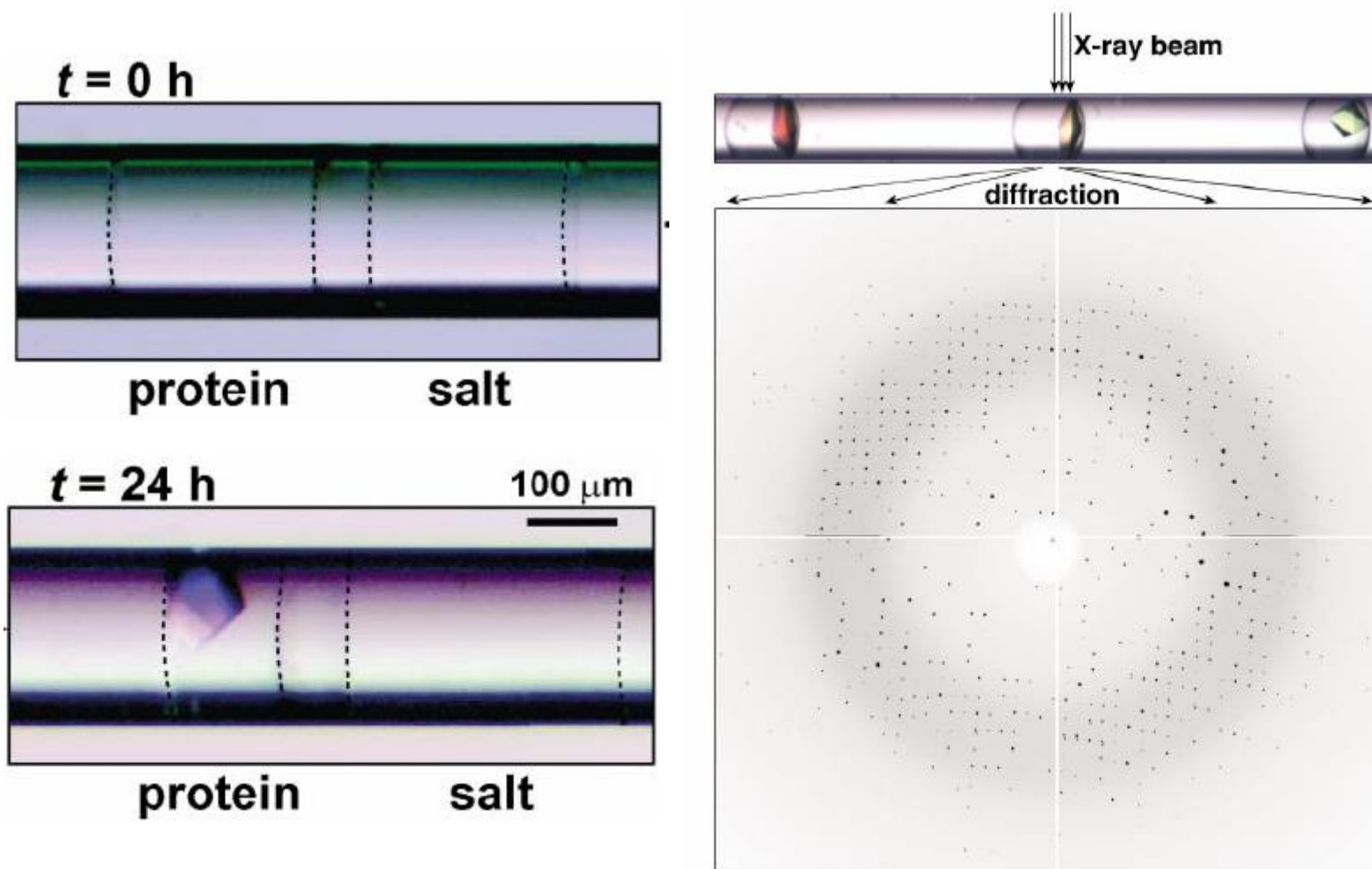


H. Song, J.D. Tice and R.F. Ismagilov, *A microfluidic network for controlling reaction networks in time*, *Angew. Chem. Int. Ed.* 42, 2003, 768-772

Protein crystallization

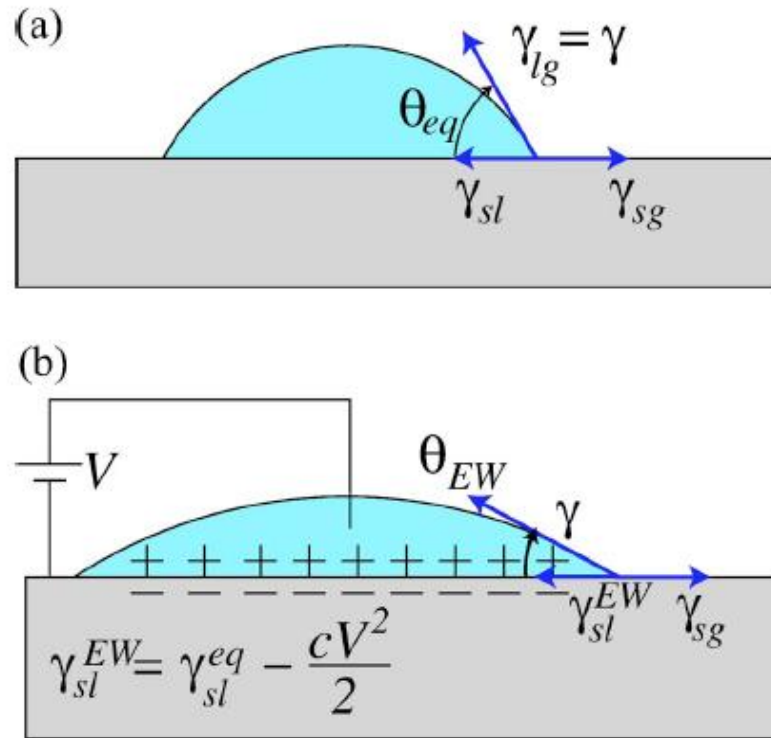


Direct X-ray analysis in capillary



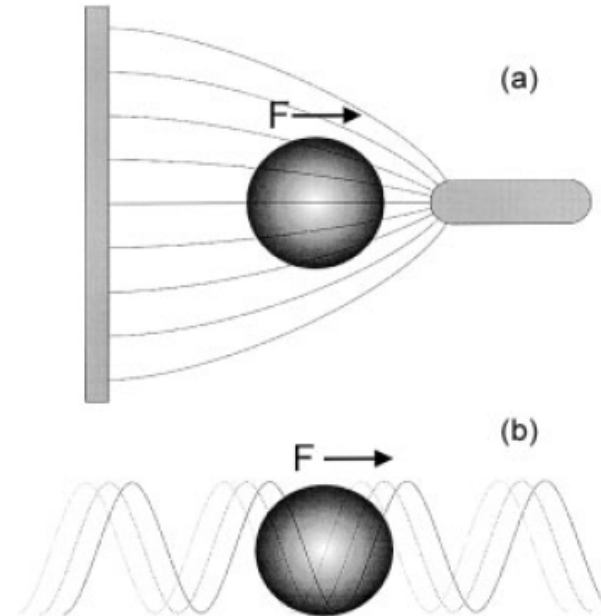
B. Zheng e.a. *Angew. Chem. Int. Ed.* 43, 2004, 2508

Electrical manipulation of droplets



Wetting and electrowetting

Review: F. Mugele e.a., J. Phys. Condens. Matter 17, 2005, p.S559



Dielectrophoresis: particle suspended in alternating E-field with magnitude or phase gradient experiences pos. or neg. forcedepending on whether particle is more or less polarizable than medium

Review: M.P. Hughes, Electrophoresis 23, 2002, 2569

Droplet manipulation by electric fields

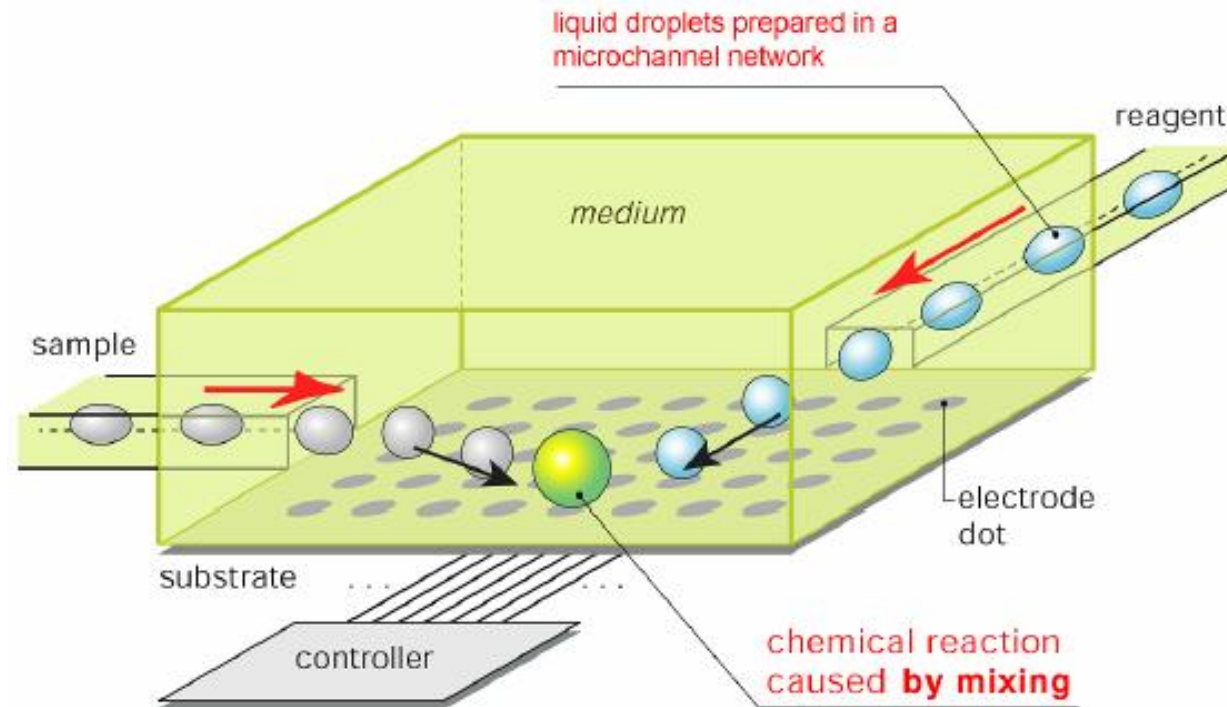
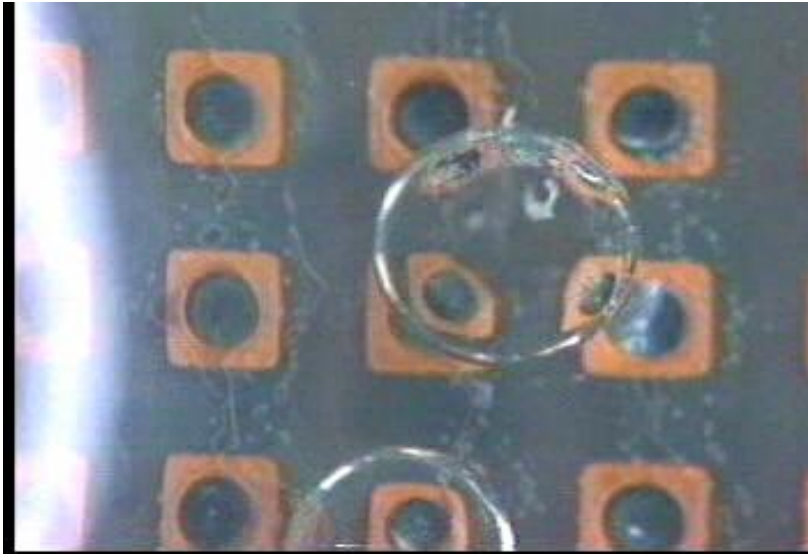


Figure 8. A schematic of the electrical actuation of micro droplets prepared in a microchannel network

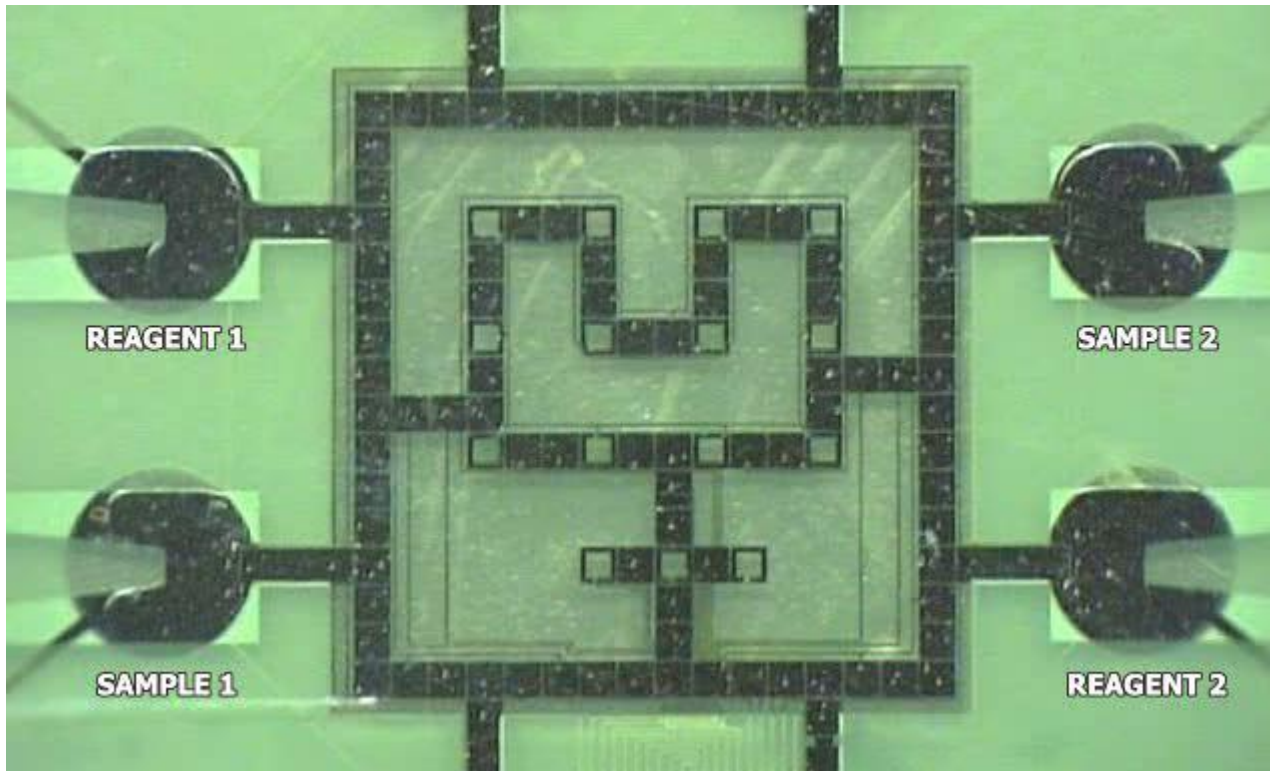
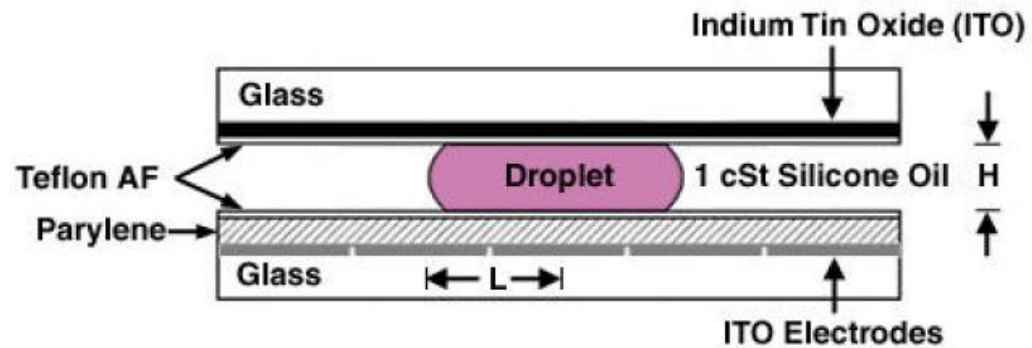
Higuchi, Torii and Yamamoto, University of Tokyo

Droplet manipulation by electric fields

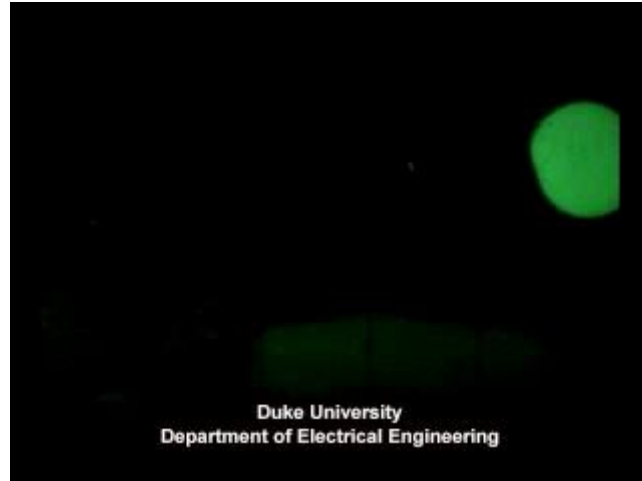
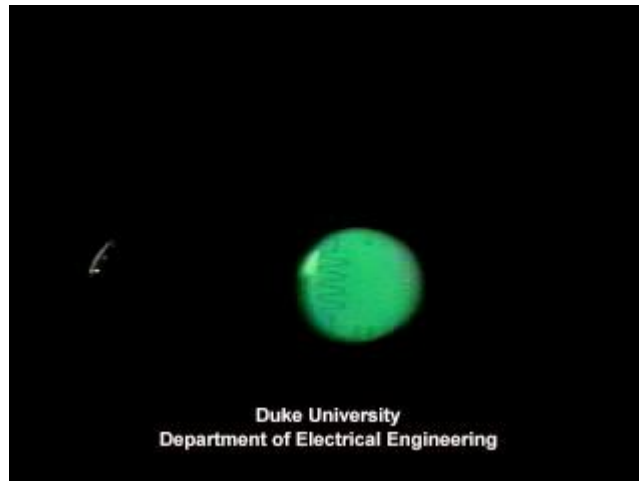
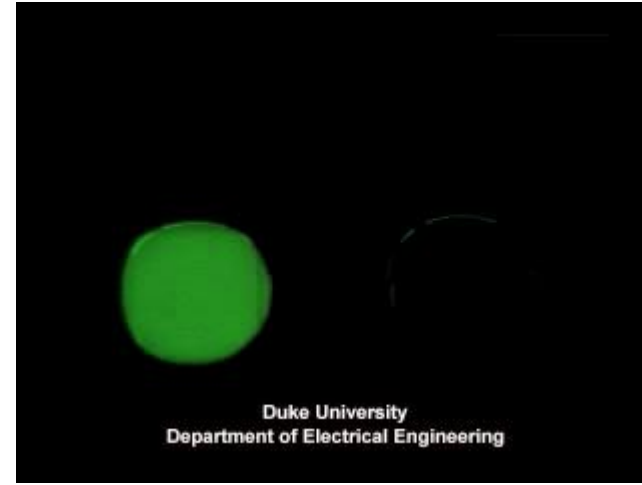
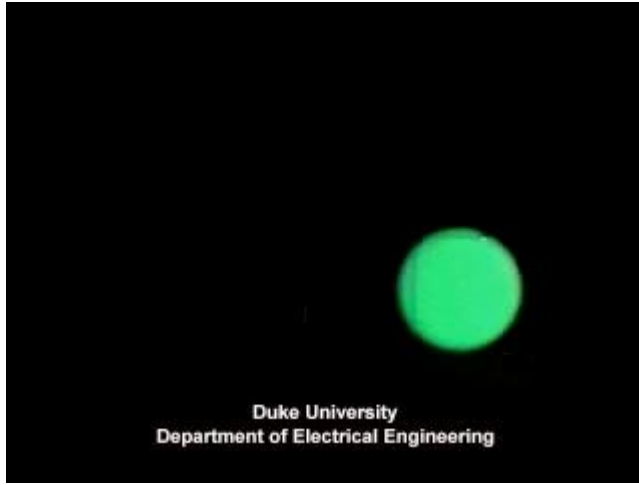


T. Taniguchi e.a. Lab Chip 2, 2002, 19

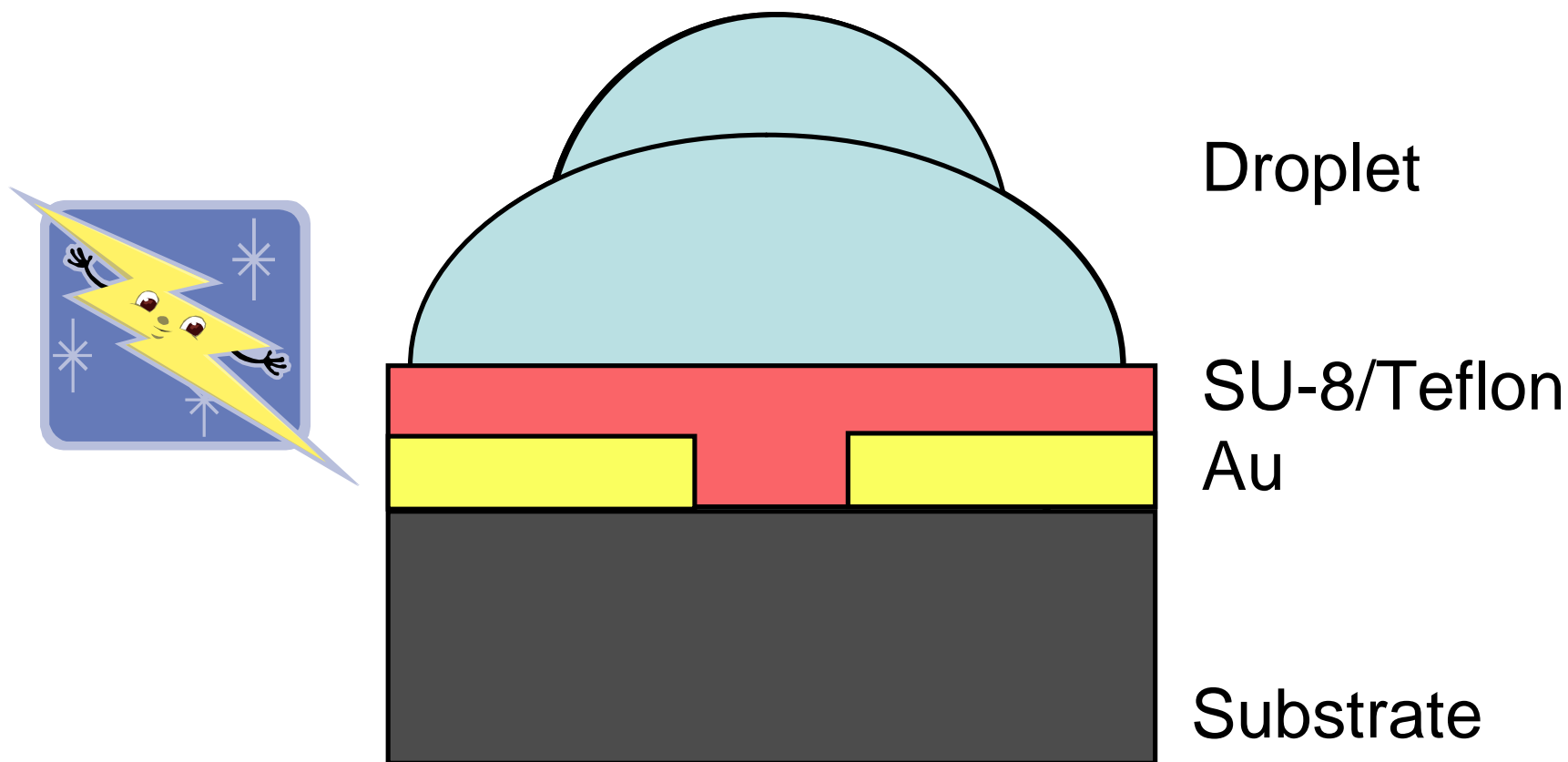
Electro wetting on dielectric (EWOD)



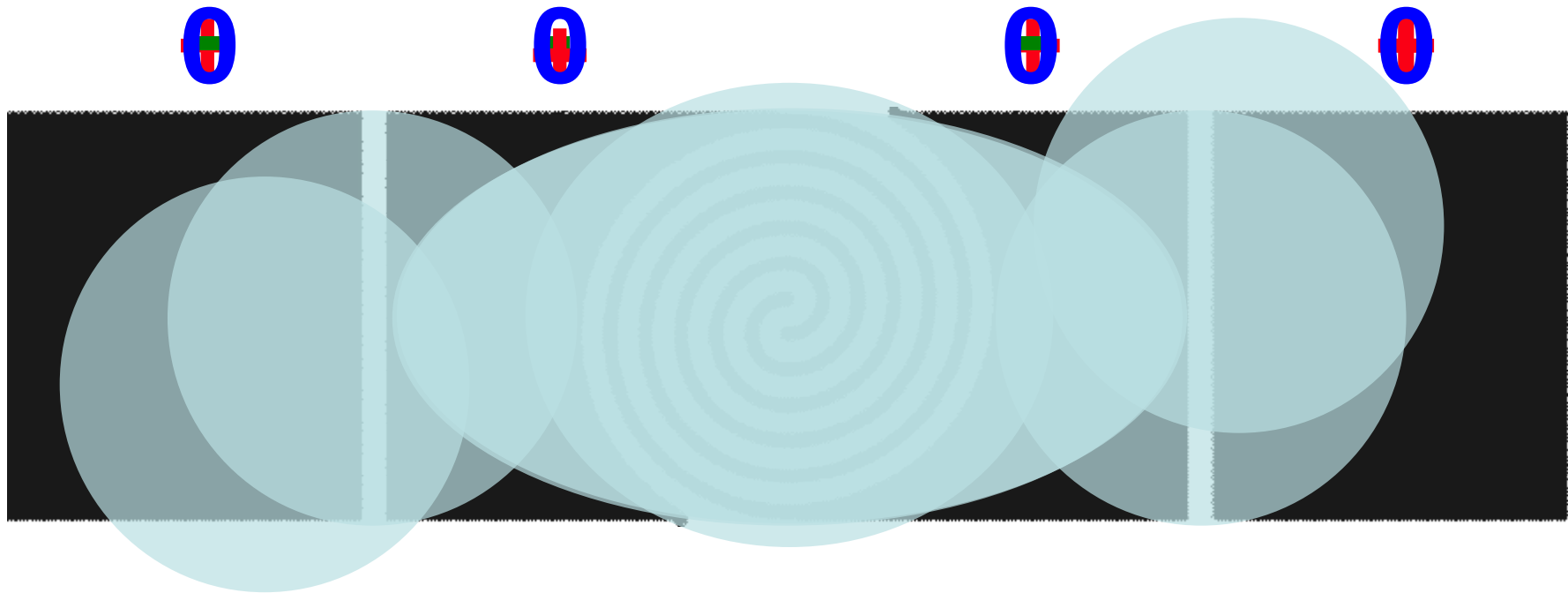
EWOD mixing



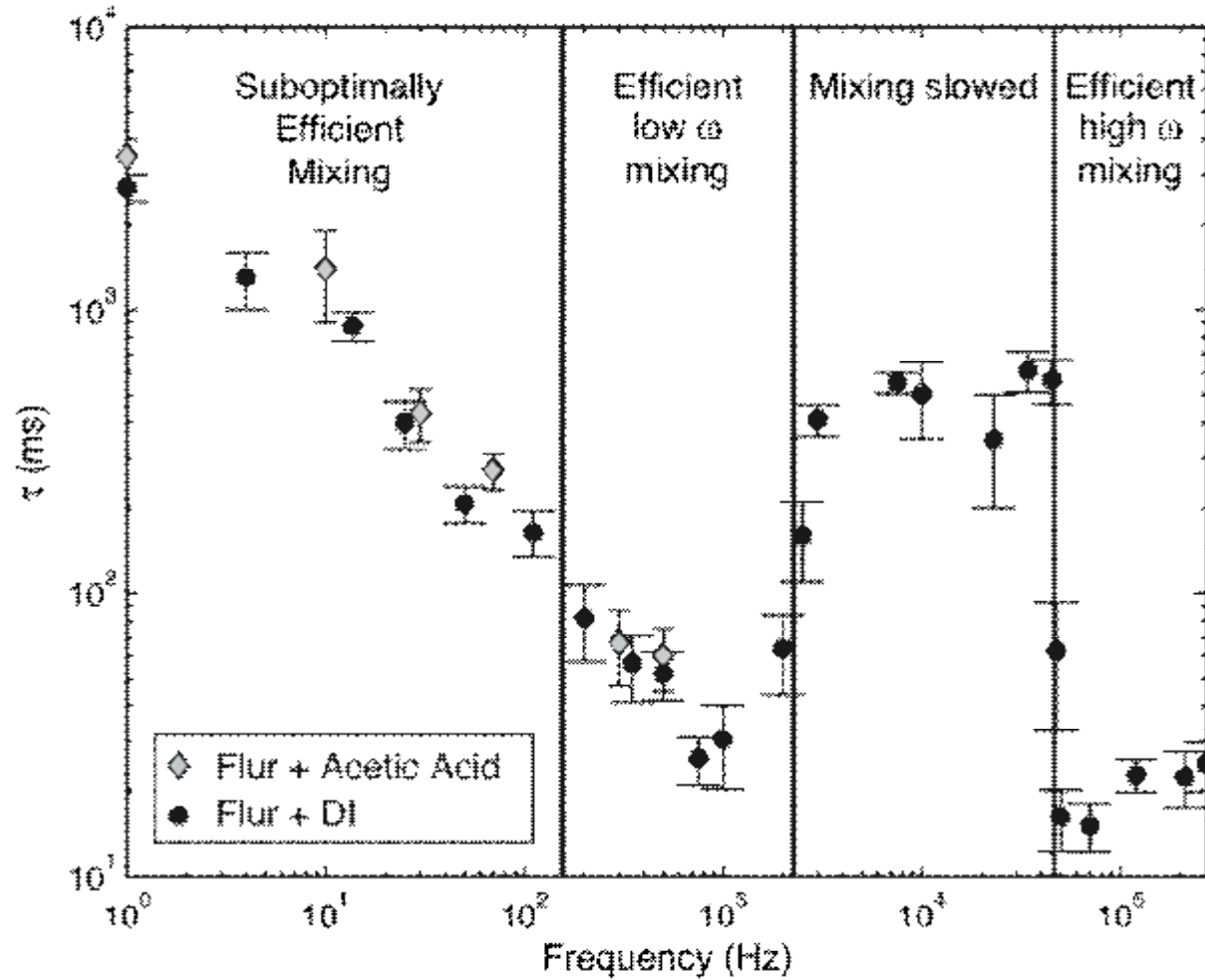
Mixer based on electro-wetting



Mixer Operation

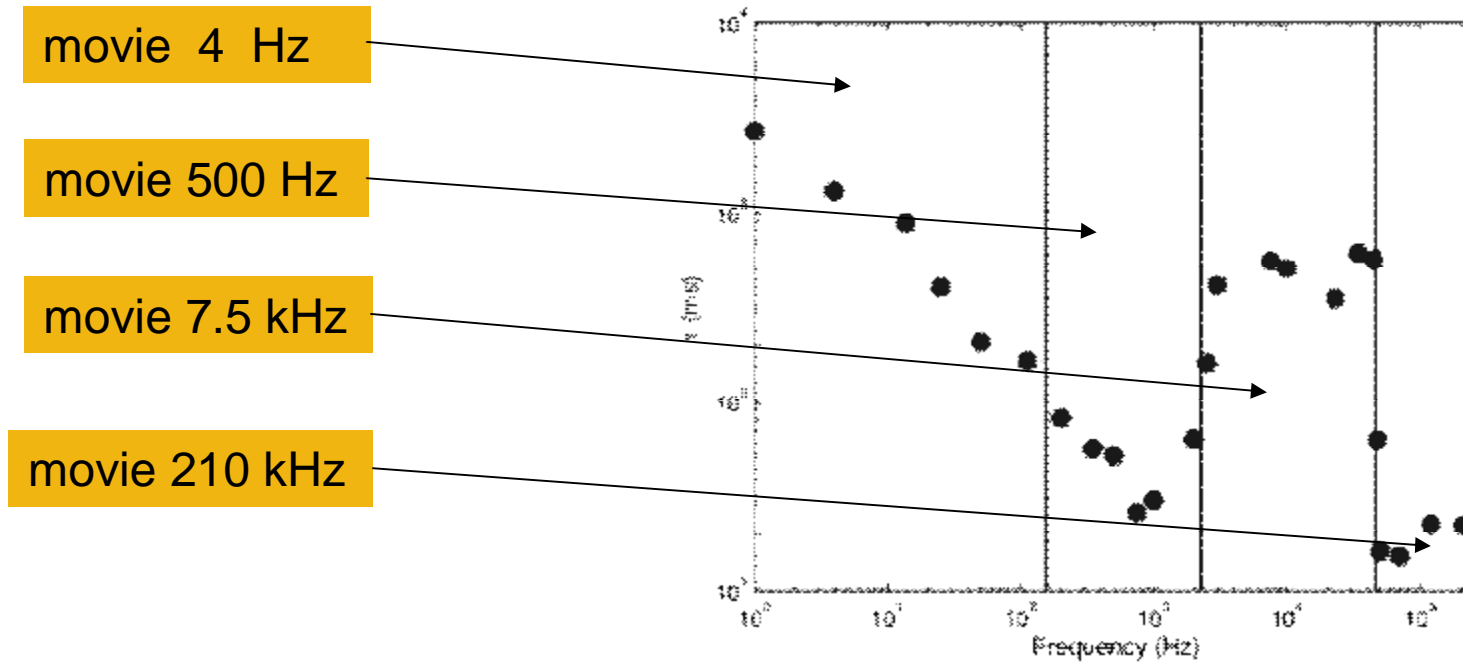


Four Mixing Regimes

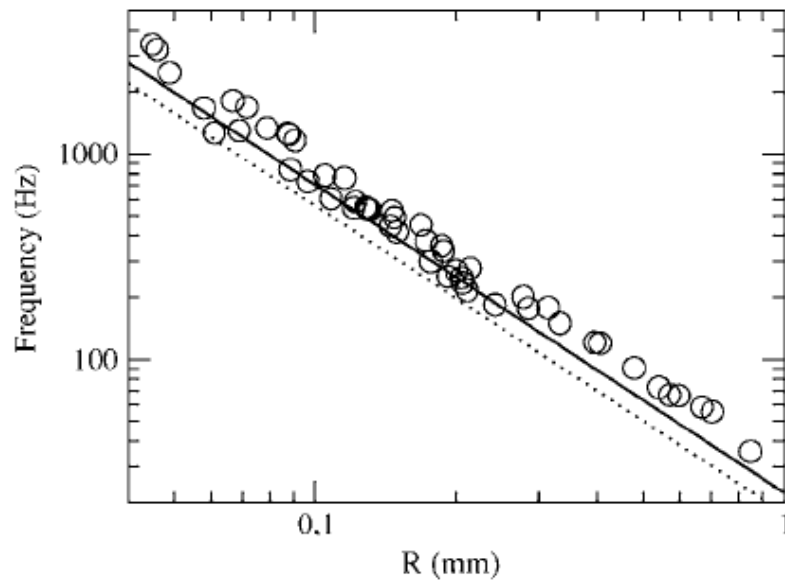


Left = DI / Right = Fluorescein

Four Mixing Regimes:

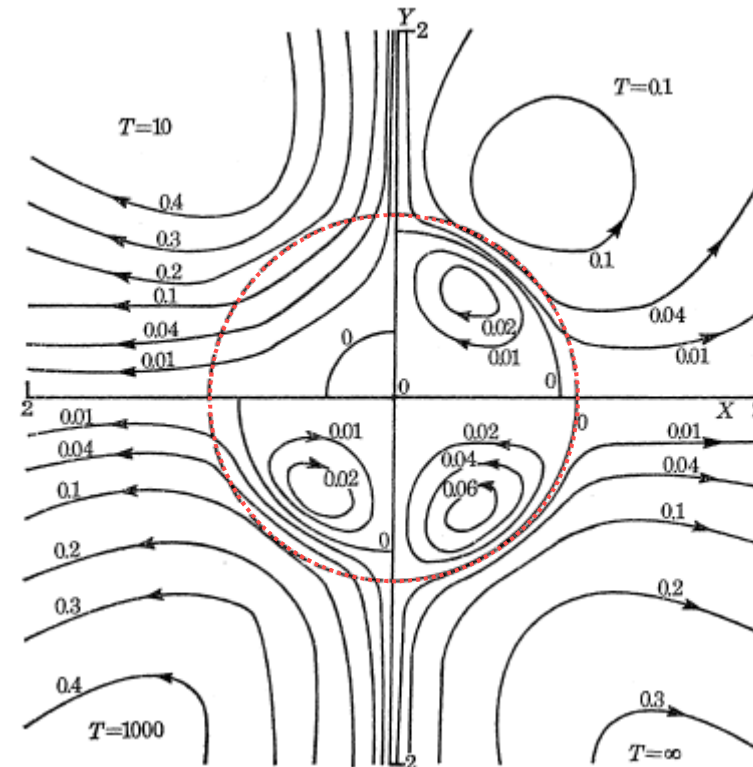


at 250 V, 500 Hz: good mixing < 20 ms
for 1 μ l droplets without Joule heating



Eigenfrequency of supported drops

F. Celestini e.a. Phys. Rev. E 73, 2006, p. 041602



Flow pattern in droplet in DC electric field along X-axis, due to electrically induced surface stresses

Sozou, Proc. Royal Soc. London A 334 (1973) 343

Enzymatic reaction kinetics by MALDI-MS

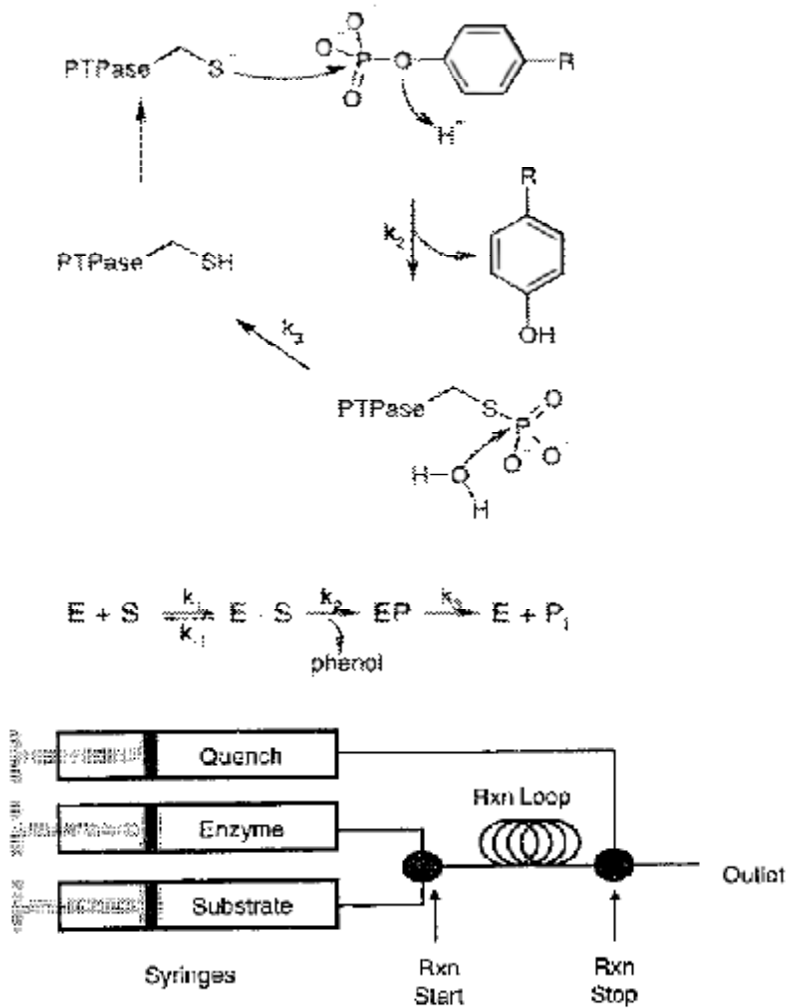
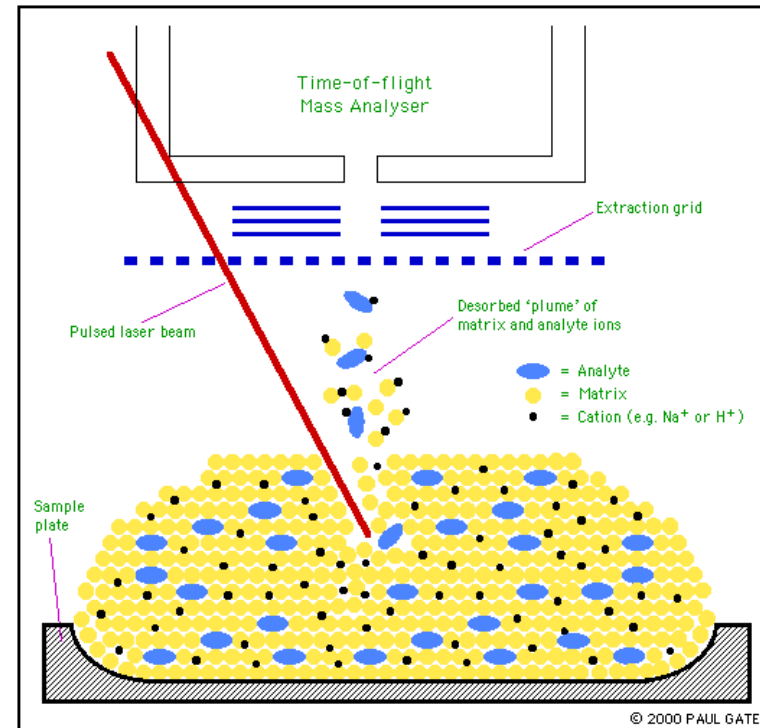


Figure 2. Block diagram of quench flow apparatus.

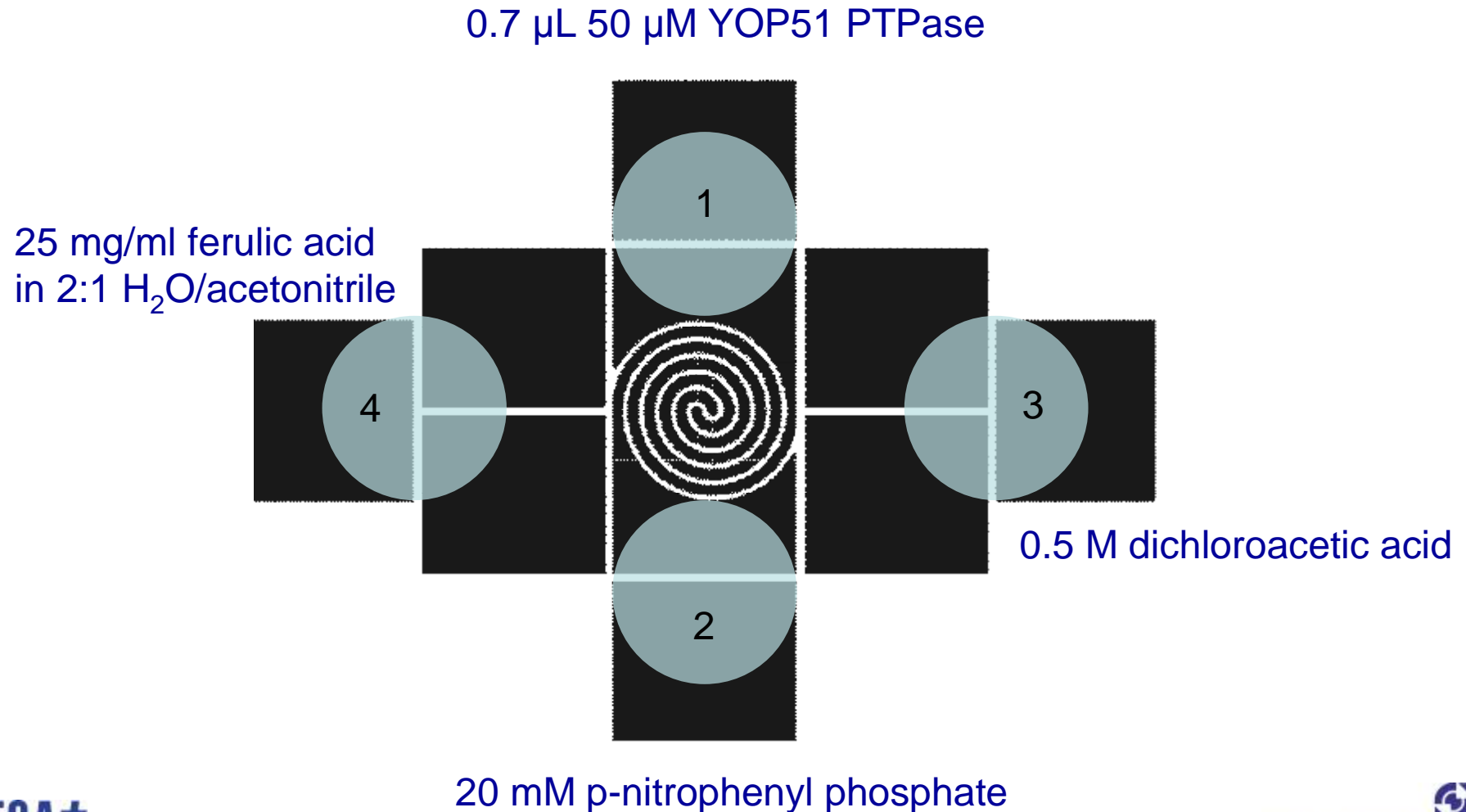
Houston et al., Anal Chem 72 (14), 2000, 3311

Protein Tyrosine Phosphatase
For $k_2 \gg k_3$, detect EP Buildup

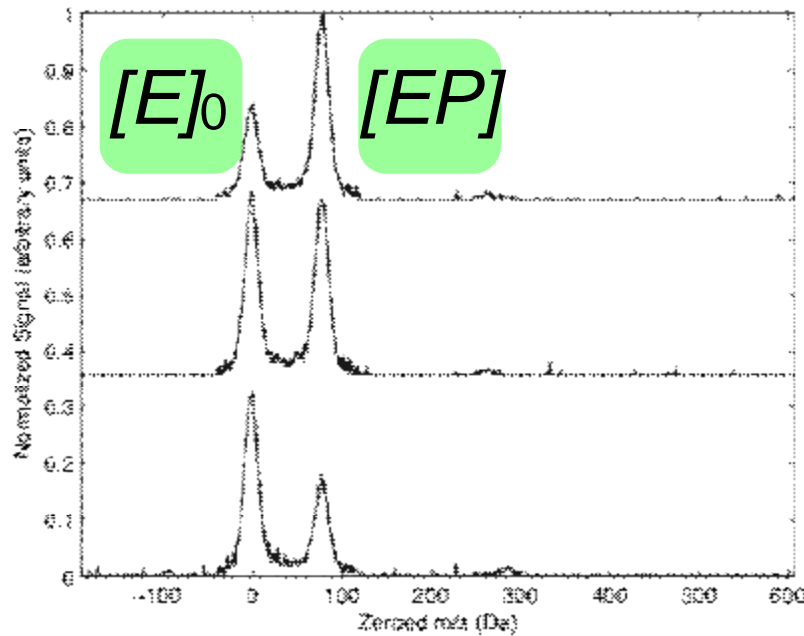


MALDI MS principle

Mixer + 2 more droplet pads



MALDI Results

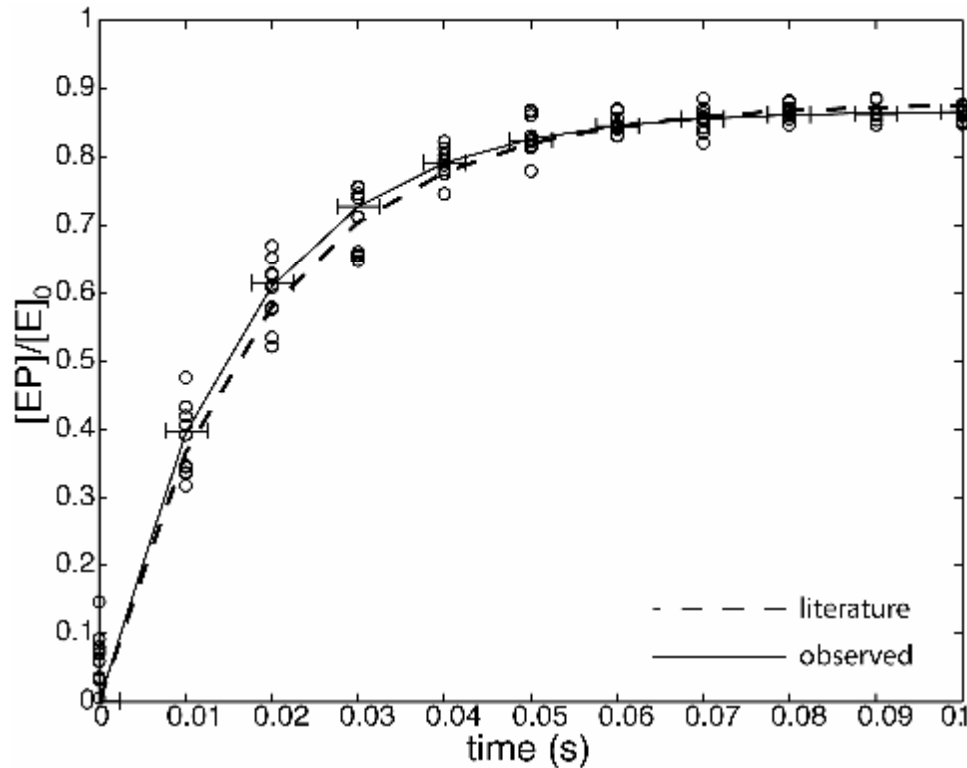


$$C = \frac{k_2 \cdot [E]_0}{(k_2 + k_3)^3 \cdot \left(1 + \frac{K_m}{[S]_0}\right)}$$

$$b = k_3 + \frac{k_2}{1 + \frac{(k_2 + k_3)K_m}{k_3 \cdot [S]_0}}$$

$$\frac{[EP]}{[E]_0} = C \cdot (1 - e^{-bt})$$

Reaction kinetics results



$$C = \frac{k_2 \cdot [E]_0}{(k_2 + k_3)^3 \cdot \left(1 + \frac{K_{m2}}{[S]_0}\right)}$$

$$b = k_3 + \frac{k_2}{1 + \frac{(k_2 + k_3) K_m}{k_3 \cdot [S]_0}}$$

$$\frac{[EP]}{[E]_0} = C \cdot (1 - e^{-bt})$$